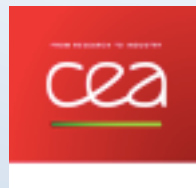


# ***Electron-phonon coupling and ultrafast dynamics of hot carriers in semiconductors.***

**Jelena Sjakste**

*Laboratoire des Solides Irradiés, CNRS, Ecole Polytechnique, CEA/DRF/IRAMIS  
Institut Polytechnique de Paris, France*



# Collaborations

## ***Ecole Polytechnique, LSI:***

N. Vast

R. Sen (post-doc)

L. Perfetti (ARPES, 2PPE)



## ***Osaka, Japan:***

K. Tanimura (ARPES, 2PPE)

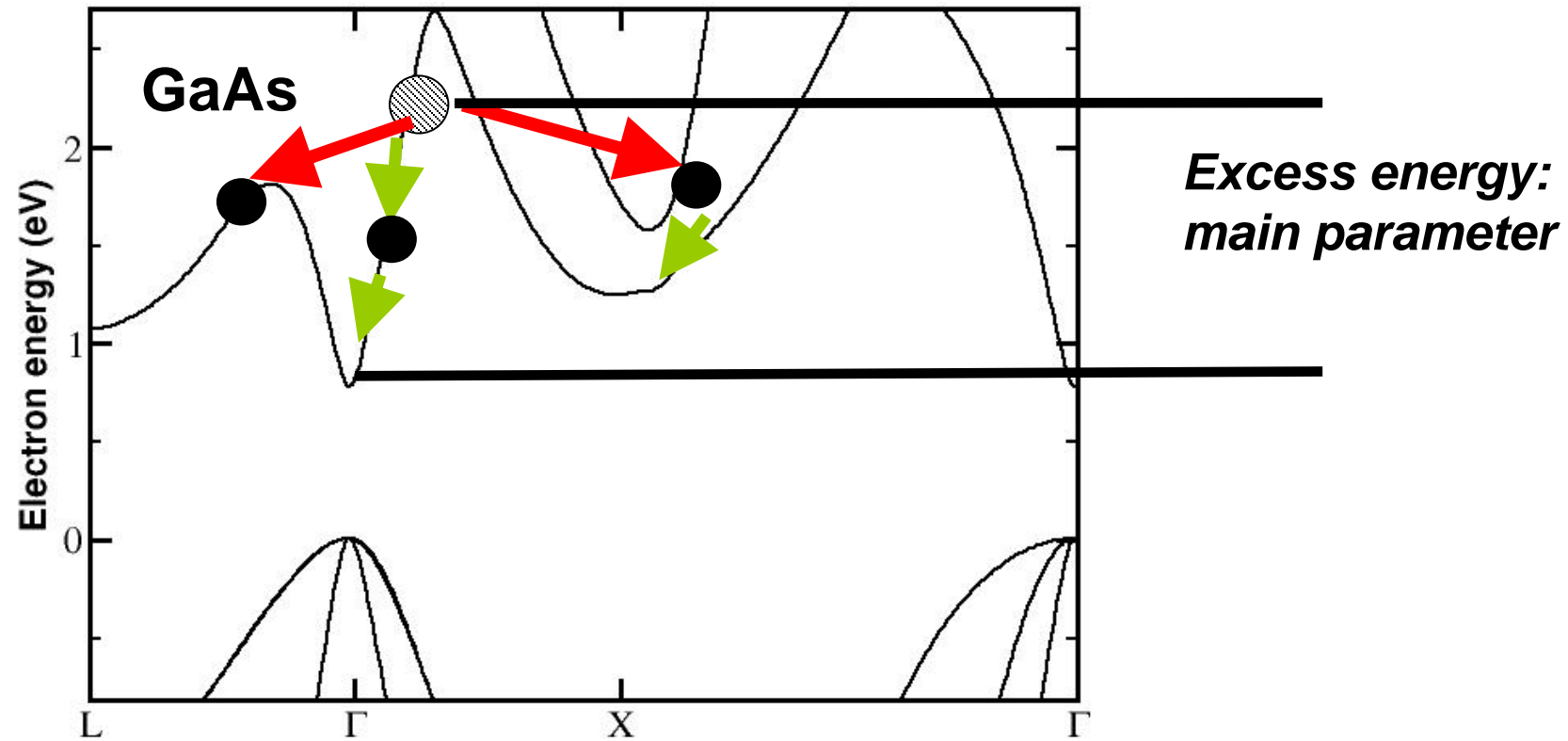
J. Kanasaki (ARPES, 2PPE)



# Outline

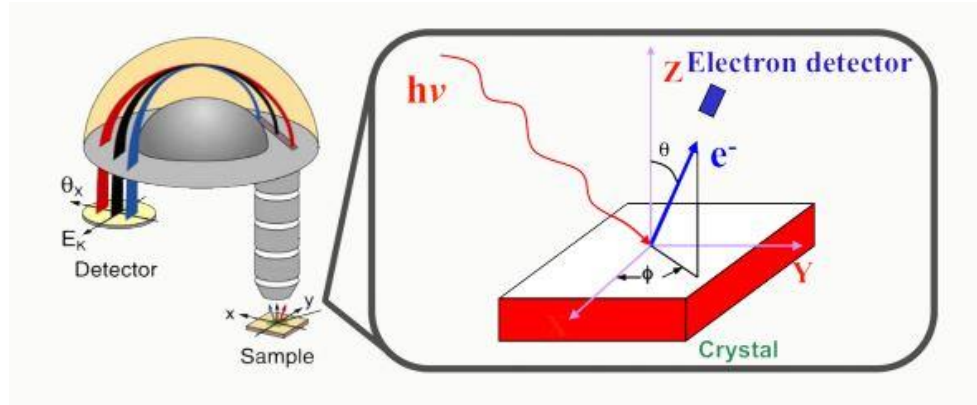
- *Electron-phonon scattering for highly excited electrons: GaAs*
- *Highly excited electron relaxation in Si and Ge*
- *Photoexcited electron relaxation in InSe*

# RELAXATION DYNAMICS OF HIGHLY EXCITED ELECTRONS



*highly non-thermal initial distributions*

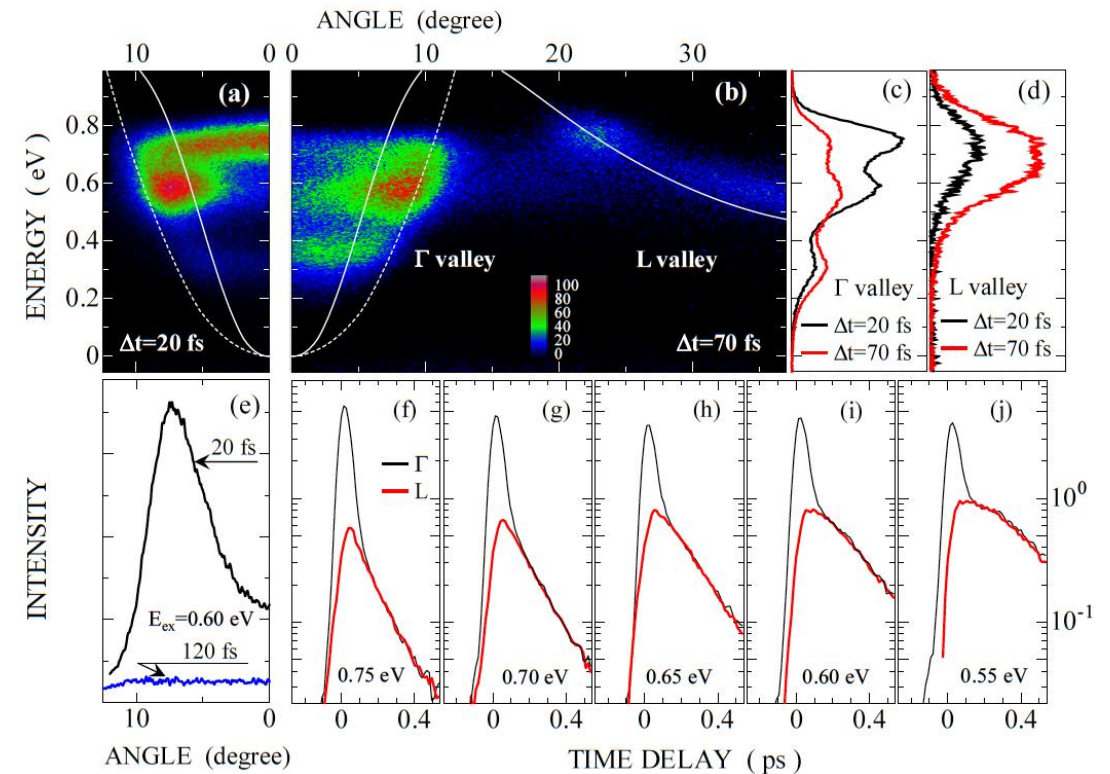
# EXPERIMENTS: ARPES



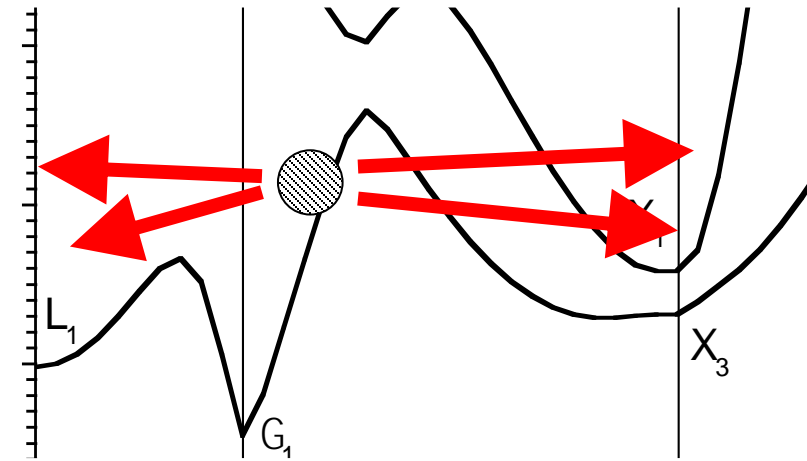
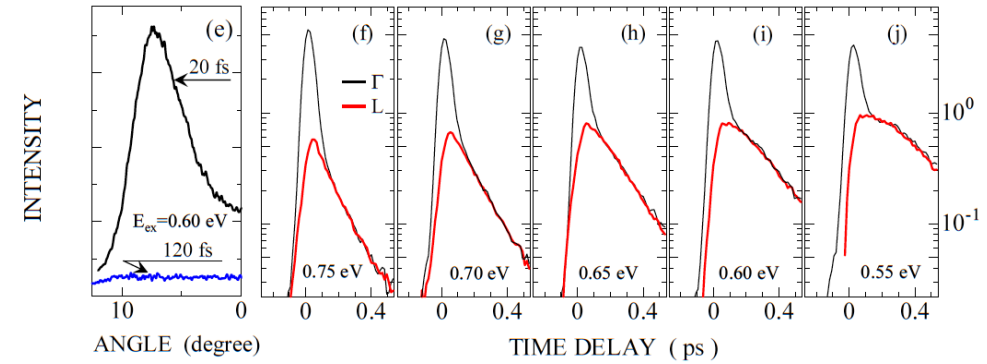
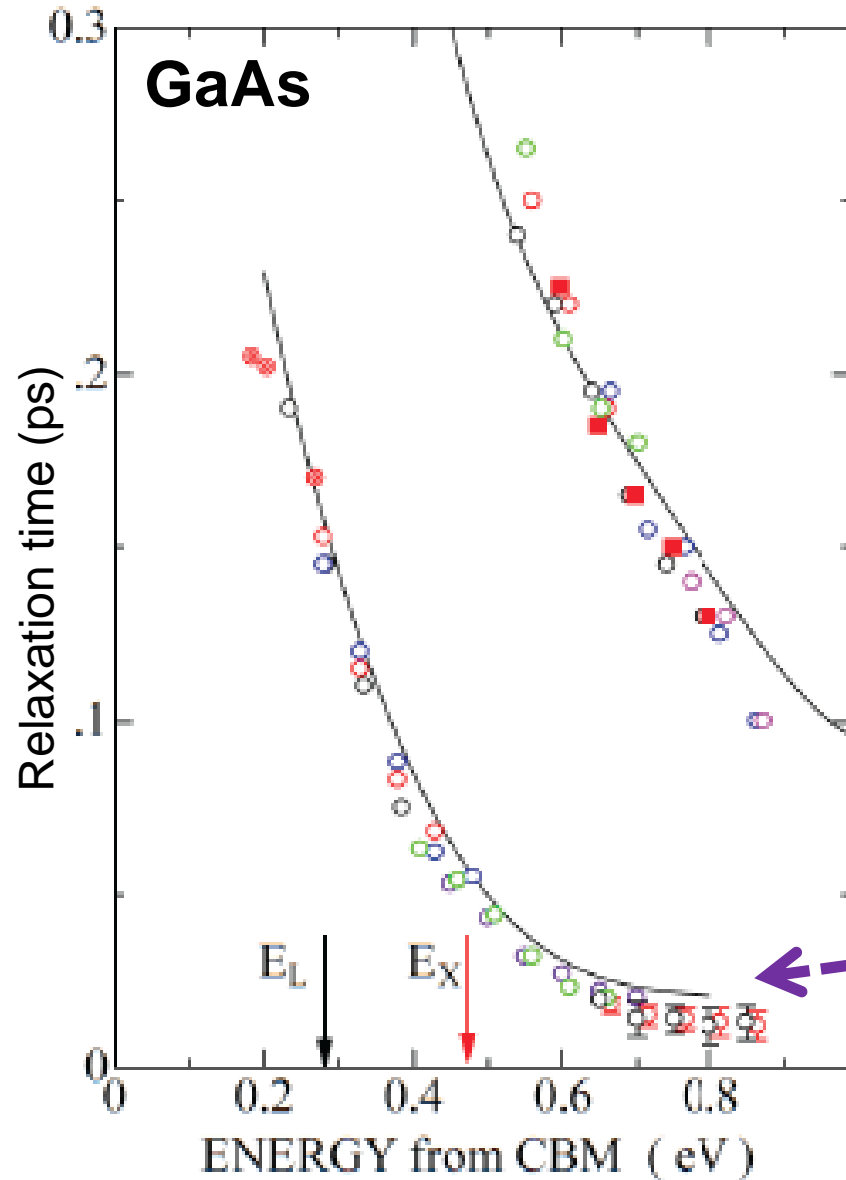
Pump and probe: 2 laser pulses at different time

GaAs  
300K

**Two distinct relaxation regimes**



# HOT ELECTRON ENSEMBLE (HEE)

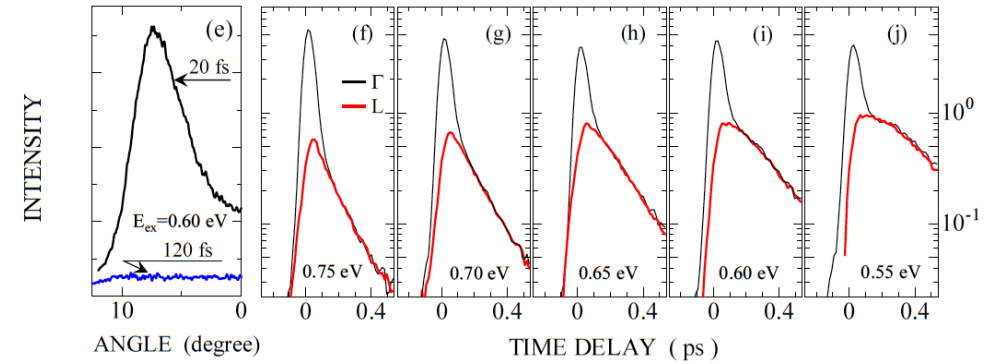
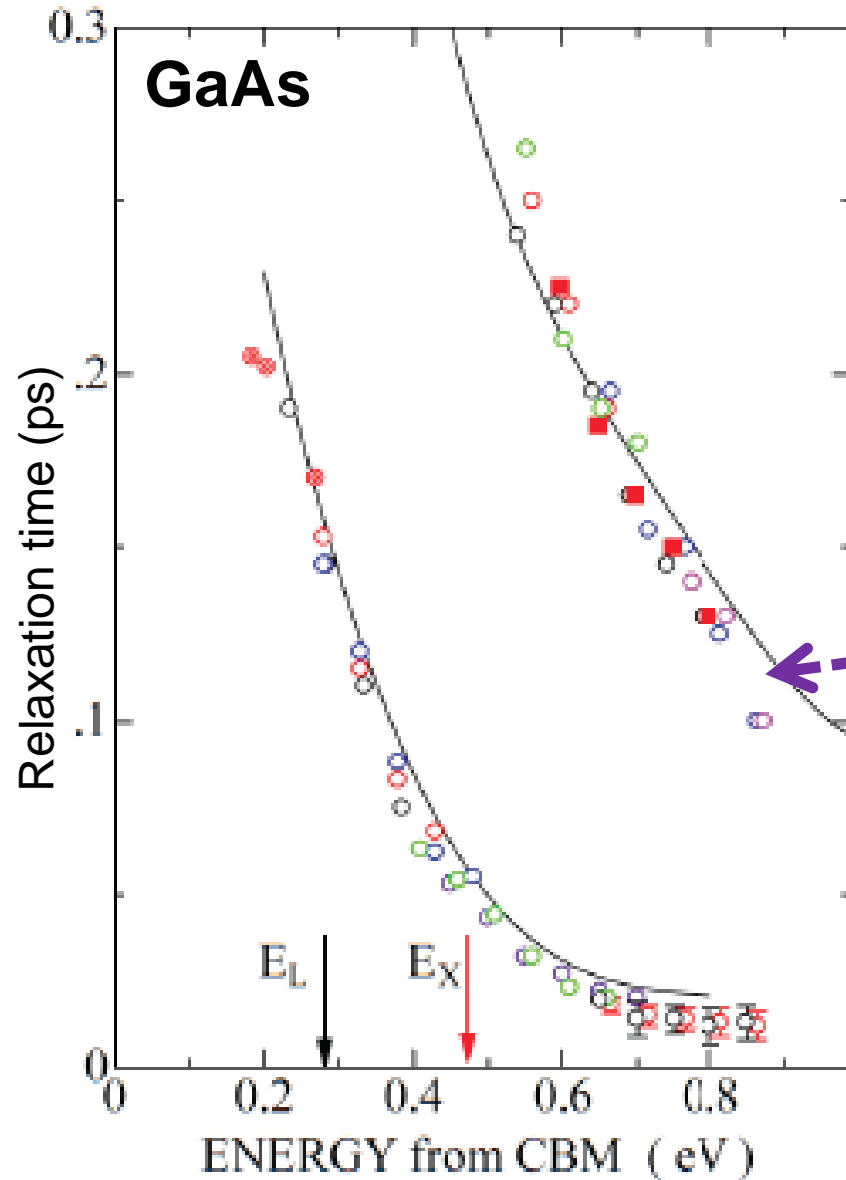


« Short » time: wavepacket spreads over BZ;  
 « isomerization »: total scattering rate,  
 mostly intervalley transitions

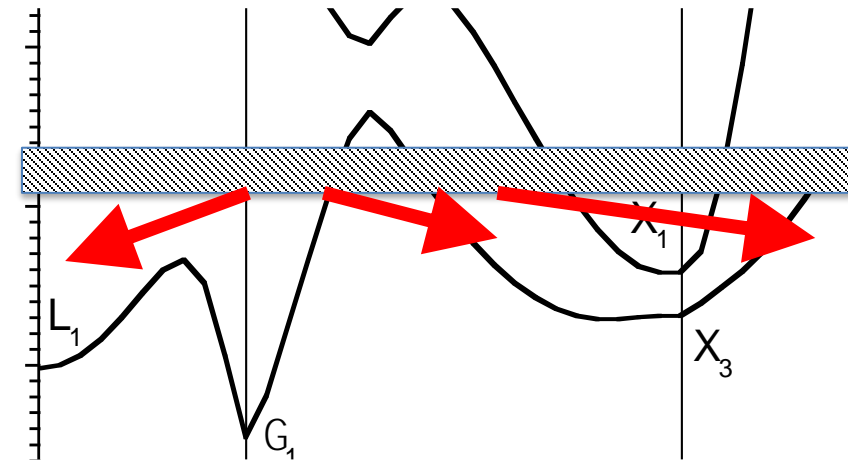
Tanimura et al, PRB 93 (2016) 161203 (R).

Sjakste et al, J. Phys: Cond. Mat. **30**, 353001 (2018).

# HOT ELECTRON ENSEMBLE (HEE)



« long » time: energy transfer  
from electrons to phonons



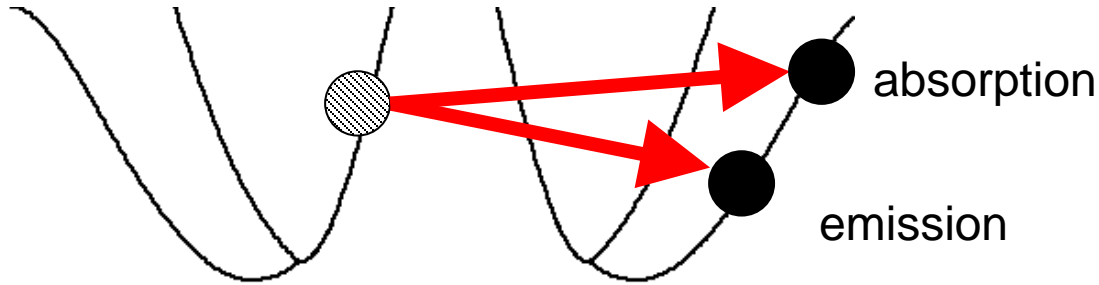
mostly intervalley transitions

Tanimura, Kanasaki, Tanimura, Sjakste, Vast, Calandra, Mauri, PRB 93 (2016) 161203 (R).

# ELECTRON-PHONON COUPLING: DFPT+ Wanner

$$\langle \Psi_{n,k} | \Delta W_q^\lambda | \Psi_{n',k+q} \rangle$$

DFPT: Baroni et al, Rev. Mod. Phys. 2001



$$\Gamma_{n,k} = \Gamma_{nk}^{em} + \Gamma_{nk}^{abs}$$

**absorption+emission**

$$\frac{d \langle E \rangle}{dt} = \Gamma_{em} \omega_{em} - \Gamma_{abs} \omega_{abs}$$

**emission-absorption**

**Wannier interpolation of the electron-phonon matrix elements:**



J. Sjakste, N. Vast, M. Calandra, F. Mauri, PRB 92 (2015) 054307  
C. Verdi, F. Giustino, PRL 115 (2015) 176401

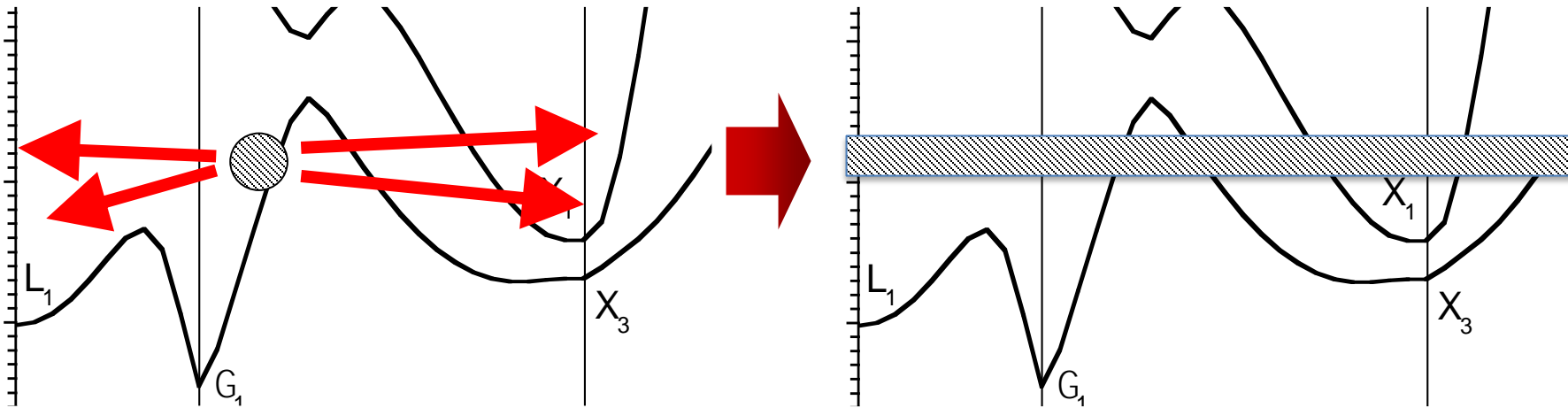
S. Ponc , E. R. Margine, C. Verdi, and F. Giustino,  
Comp. Phys. Commun. 209, 116 (2016).



# ELECTRON-PHONON SCATTERING: HIGHLY EXCITED ELECTRONS

➔ « *Randomisation* » of initial momentum

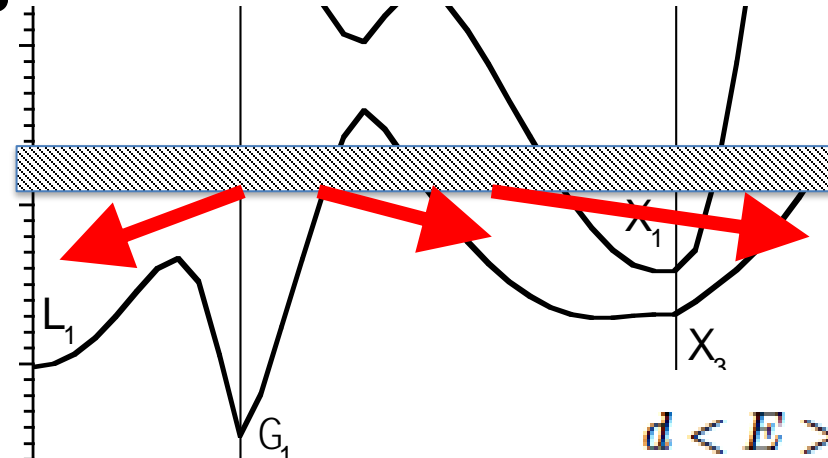
some fs - some tens of fs



$$\Gamma_{n,k} = \Gamma_{nk}^{em} + \Gamma_{nk}^{abs}$$

➔ *Energy transfer to phonons*

10 times slower

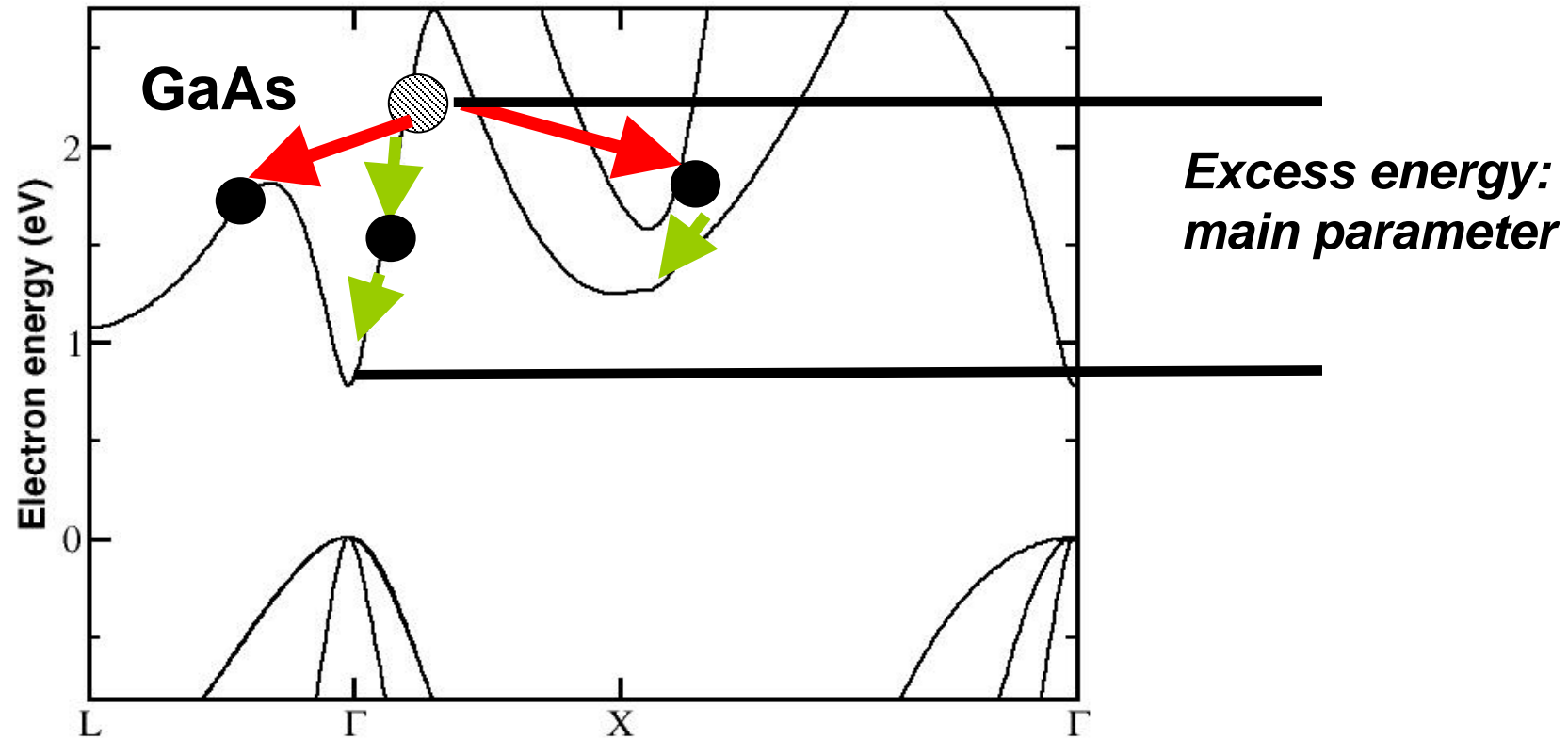


$$\frac{d \langle E \rangle}{dt} = \Gamma_{em} \omega_{em} - \Gamma_{abs} \omega_{abs}$$

Tanimura et al, PRB 93 (2016) 161203 (R).

Sjakste et al, J. Phys: Cond. Mat. **30**, 353001 (2018).

# MAIN SCATTERING CHANNELS



➡ Below second CBM in polar materials : polar optical (Fröhlich) scattering

➡ Above second CBM: intervalley scattering

# Outline

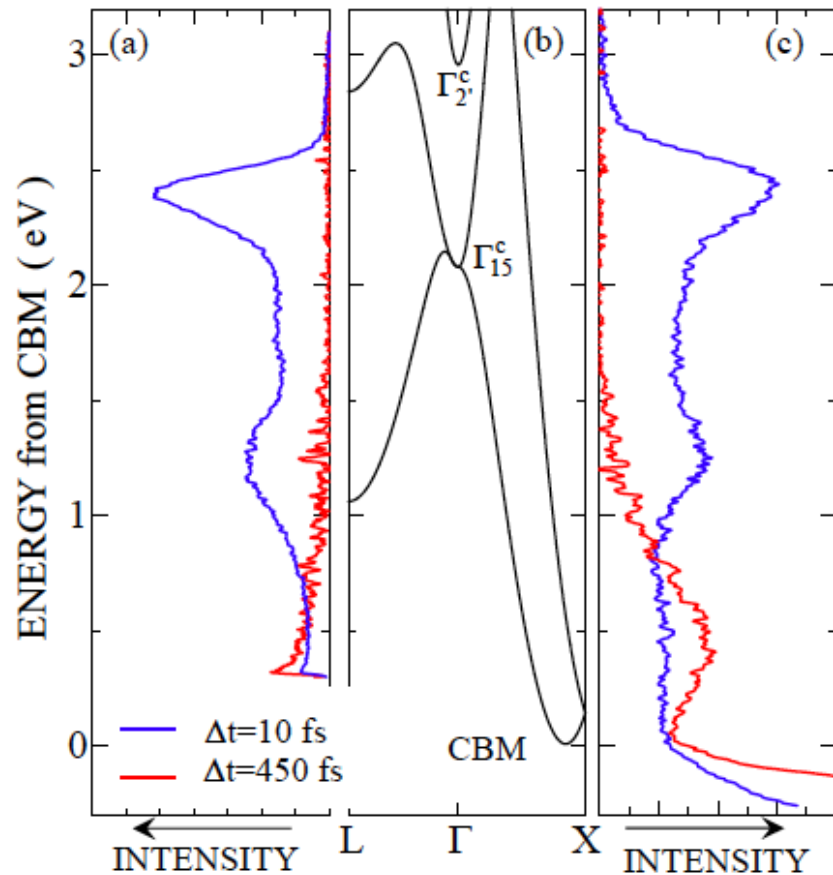
- *Electron-phonon scattering for highly excited electrons*



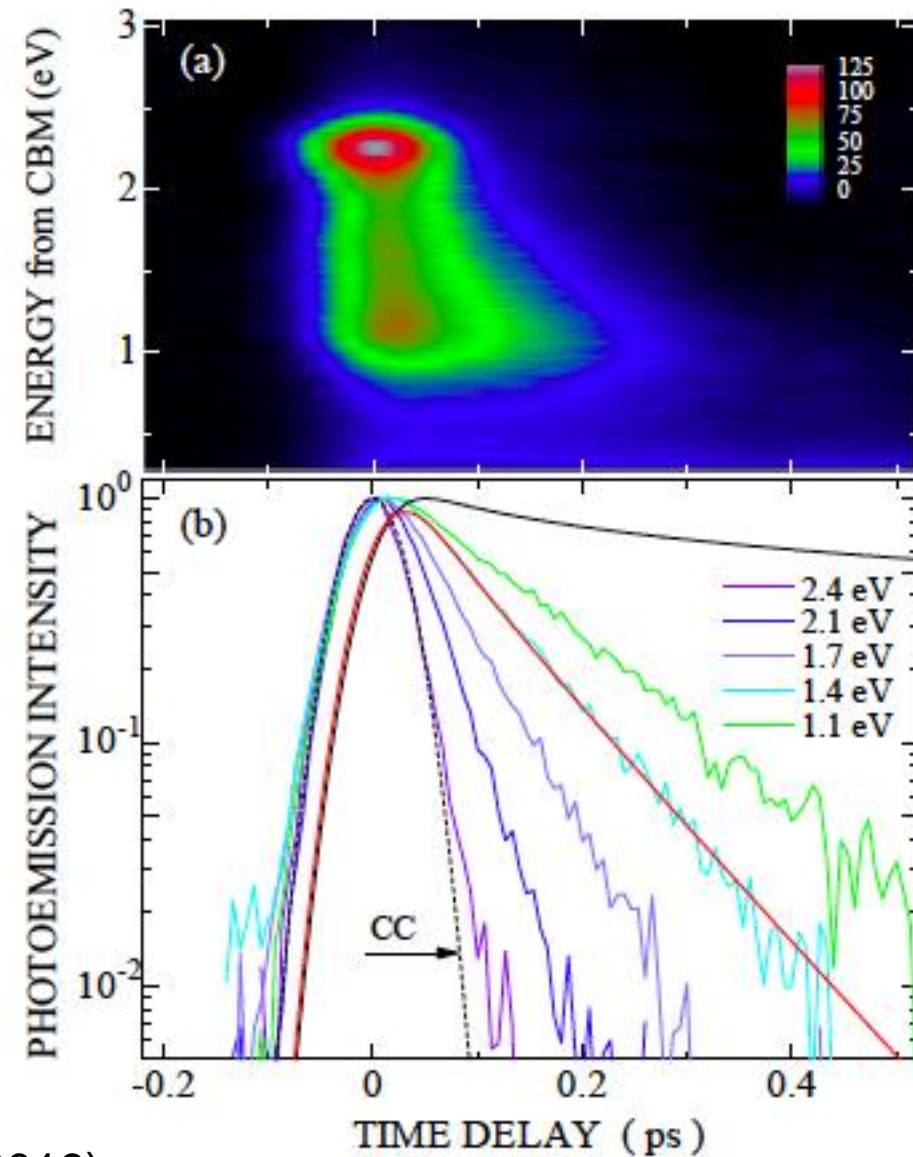
- *Highly excited electron relaxation in Si and Ge*

- *Photoexcited electron relaxation in InSe*

# HIGHLY EXCITED ELECTRONS IN SILICON: 2PPE



Excess energies: 1-3 eV above CBM



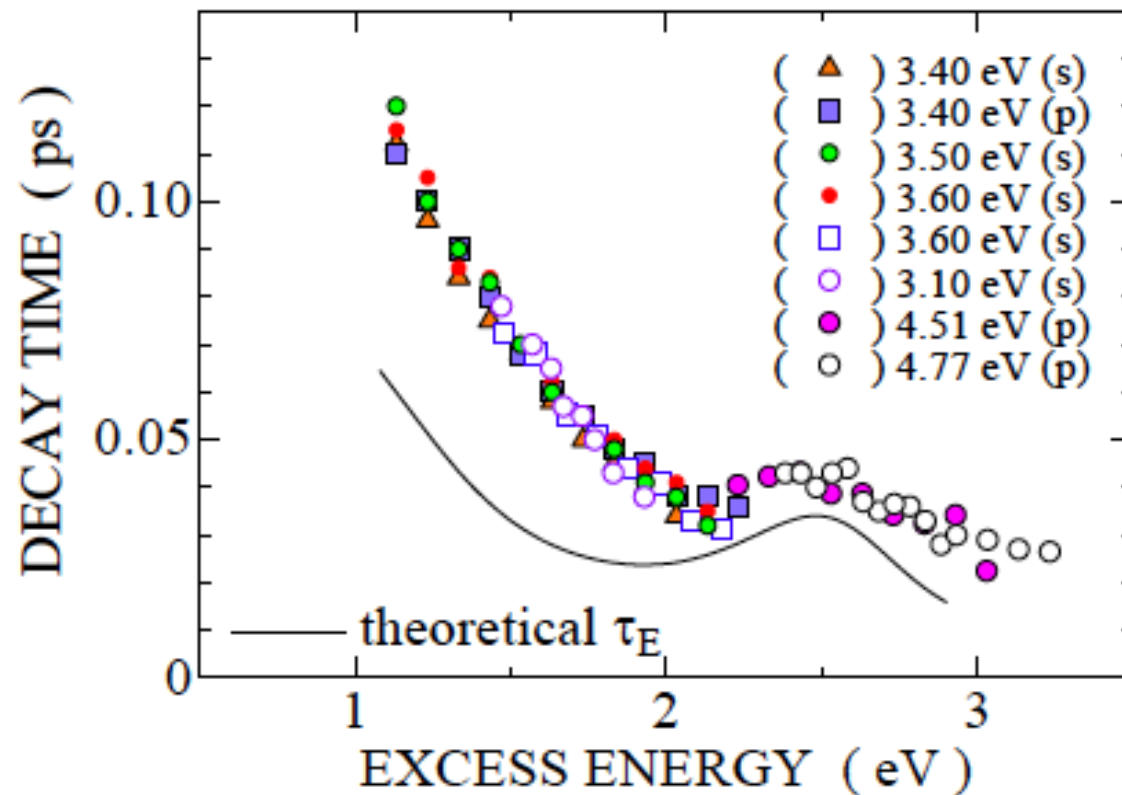
Tanimura et al, PRB 100, 03520 (2019).

# HIGHLY EXCITED ELECTRONS IN SILICON: INTERPRETATION PROBLEM

Previous work: conflict theory/experiment:

*Measured relaxation times 10 times longer than calculated ones*

Ichibayashi *et al*, Phys. Rev. B 84, 235210 (2011).



Tanimura, Kanasaki, Tanimura, Sjakste, Vast PRB **100**, 03520 (2019).

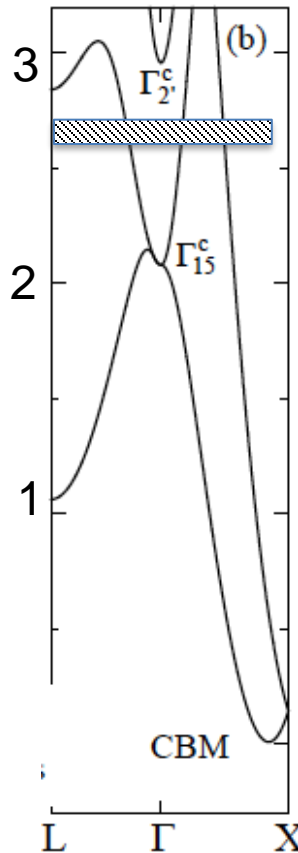
This work: HEE idea




Initial relaxation:  
***too fast to be measured***



Measured relaxation times:  
***energy loss***



# Outline

- *Electron-phonon scattering for highly excited electrons*
- *Highly excited electron relaxation in Si and Ge*
-  - *Photoexcited electron relaxation in InSe*

# Photoexcited electron relaxation in InSe

Luca PERFETTI  
Zhesheng CHEN  
Zailan ZHANG  
Raphael CABOUAT  
Jelena SJAKSTE  
Cristine GIORGETTI  
Valerie VENIARD  
Abdelkarim Ouerghi  
Hugo Henck



Evangelos PAPALAZAROU  
Marino MARSI



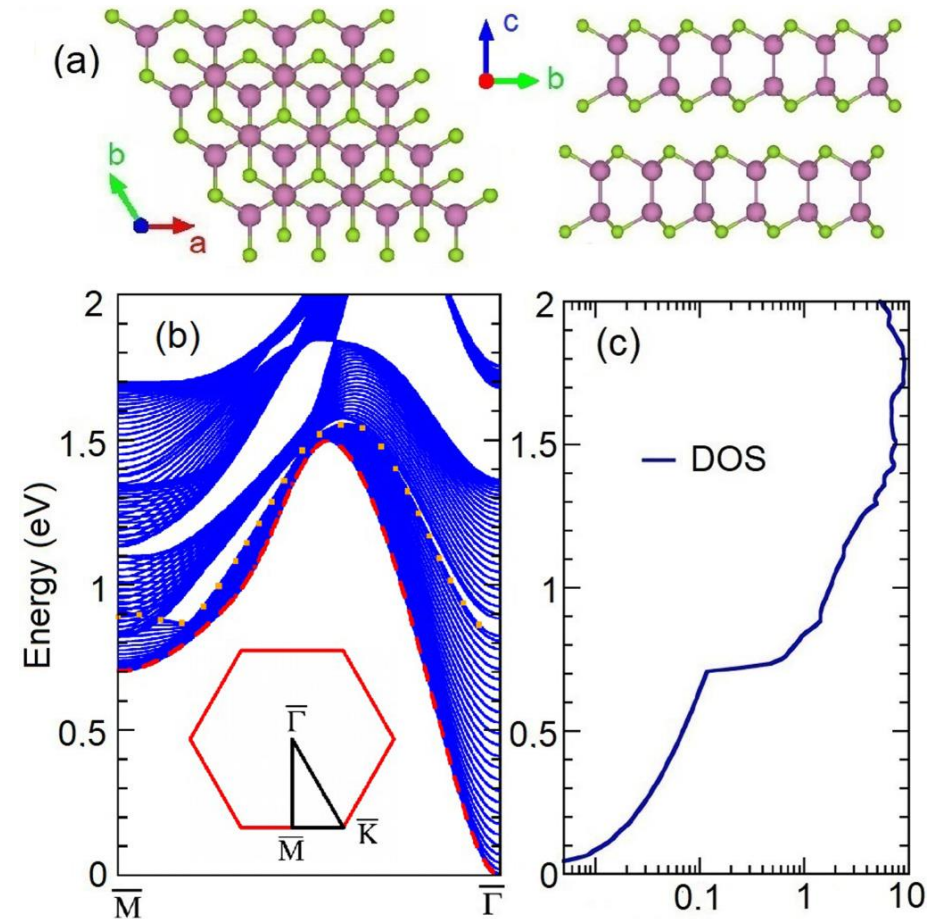
Layered material



Very narrow  $\Gamma$  valley

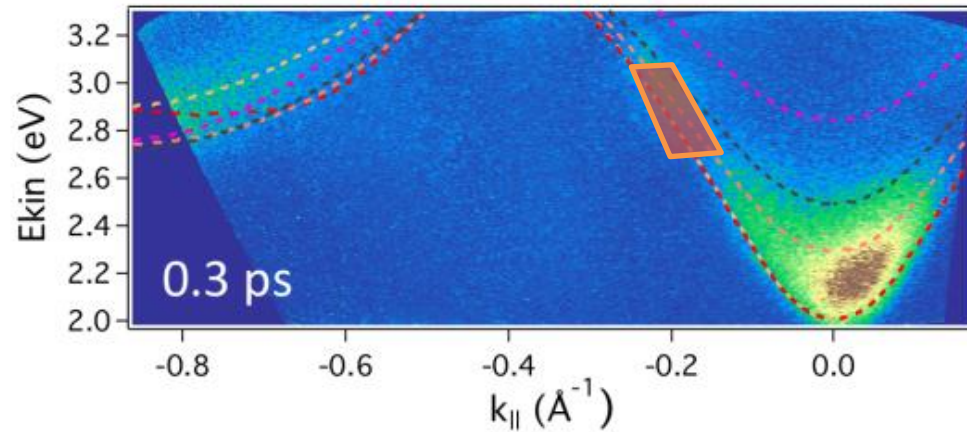


Large M valley



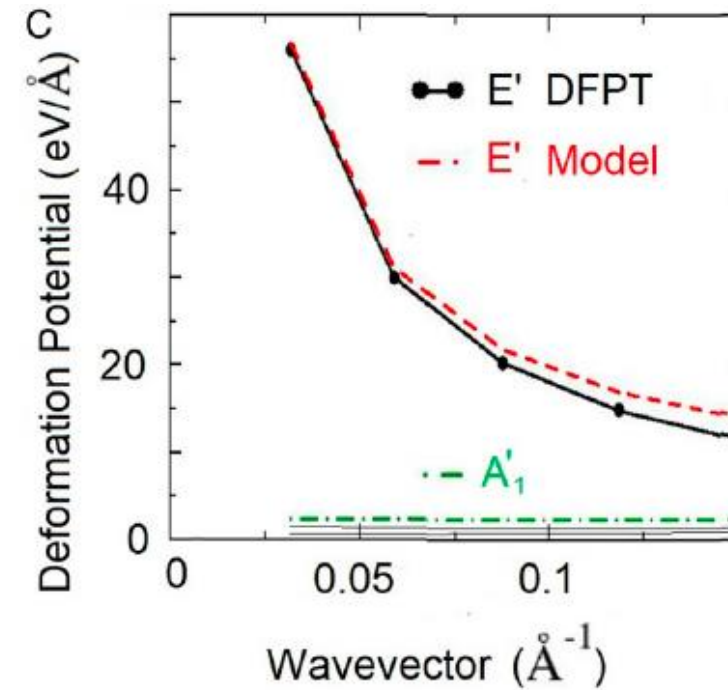


# InSe: energy relaxation in $\Gamma$ valley



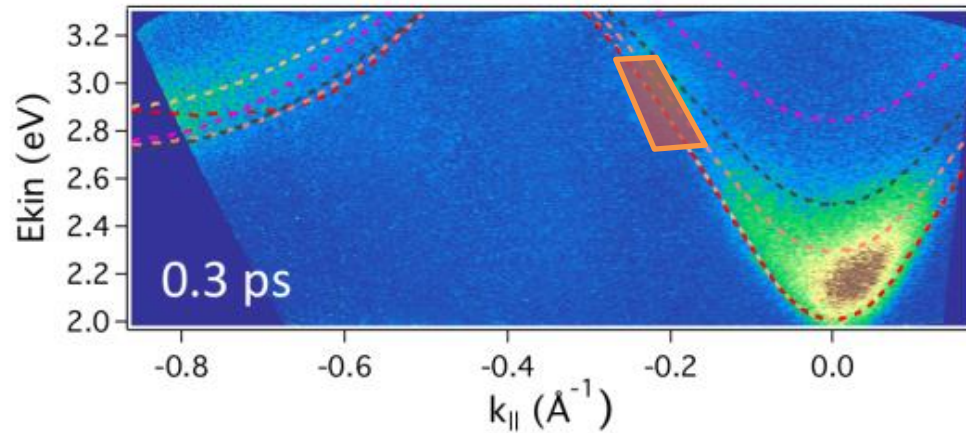
Excess energy below 0.7eV

- ➔ no intervalley scattering
- ➔ very narrow  $\Gamma$  valley ( $q < 0.2$  ang.)
- ➔ **Fröhlich scattering**  
(scattering by polar phonons)



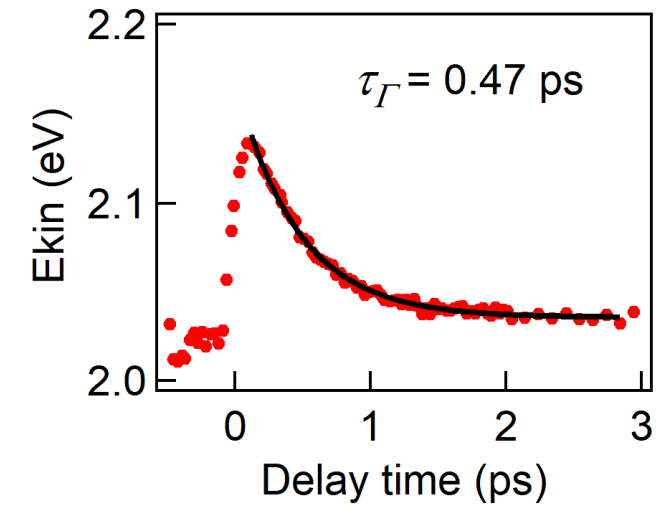


# InSe: energy relaxation in $\Gamma$ valley

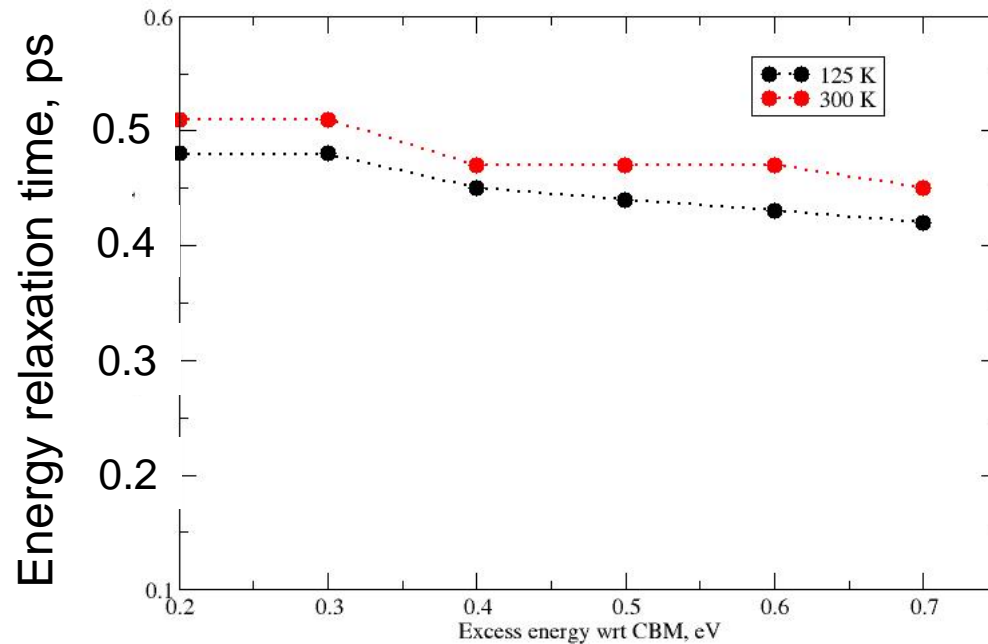


below 0.7 eV

Experiment



Theory: energy transfer due to coupling with polar phonons



scattering by polar phonons

$$\frac{4\pi e}{\epsilon_{\infty} q^2} q_{\mu} \sum_{\alpha} Z_{\mu\lambda}(\alpha) e_{\lambda}(\alpha \hat{q})$$

➔ Good agreement between theory and experiment.

# Quasi-two-dimensional gas on InSe

Experiment:

Zhesheng CHEN  
Luca PERFETTI

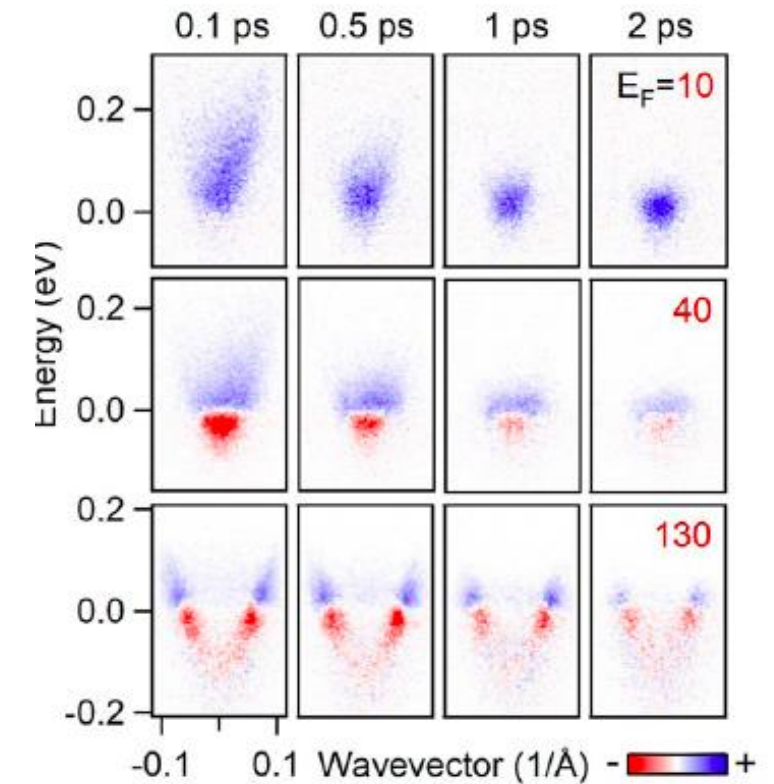
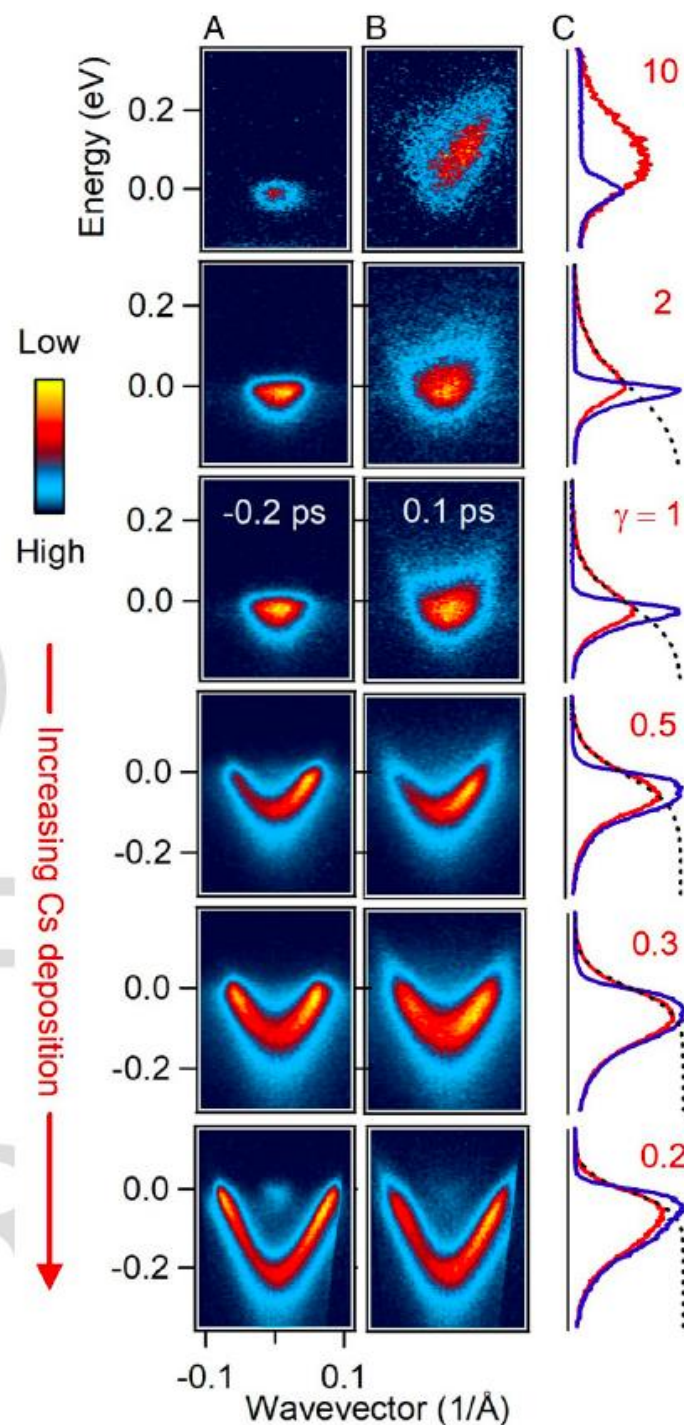


★ Increasing Cs deposition on  
InSe surface



electron gas created on the  
surface

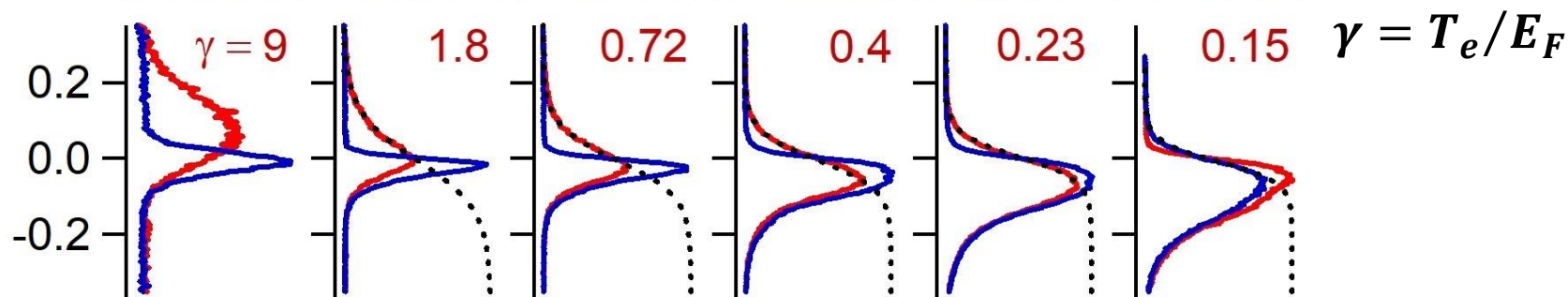
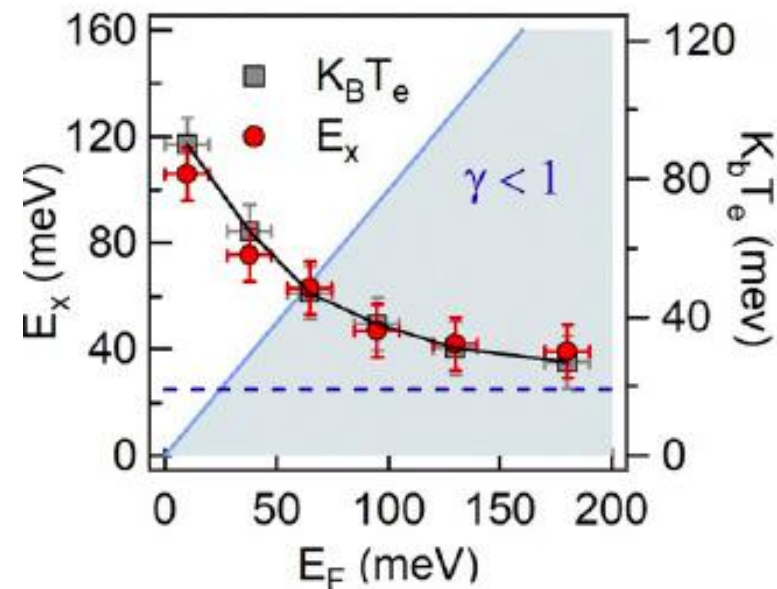
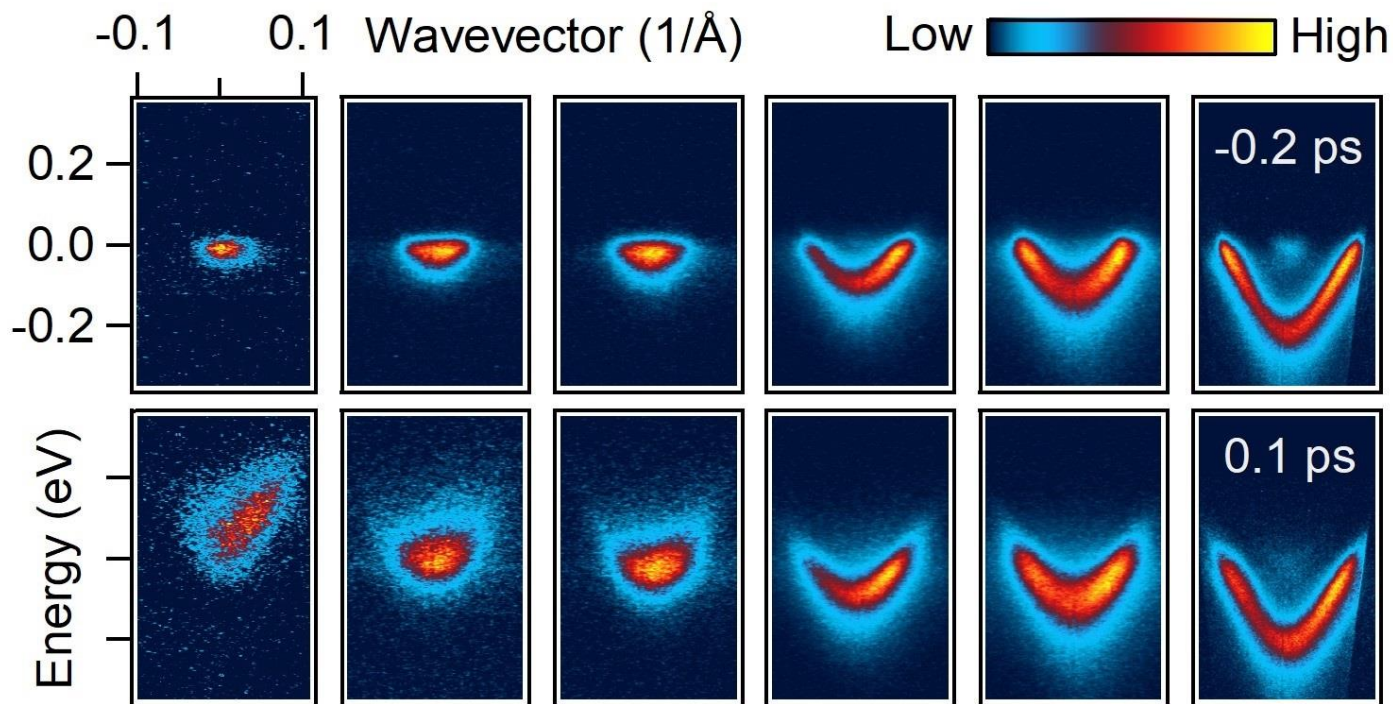
★ Dynamics of excited electrons  
studied by tr-ARPES



C

Chen, Sjakste et al, PNAS 117, 21962-21967 (2020)

# Photoexcited electrons and 2D gas



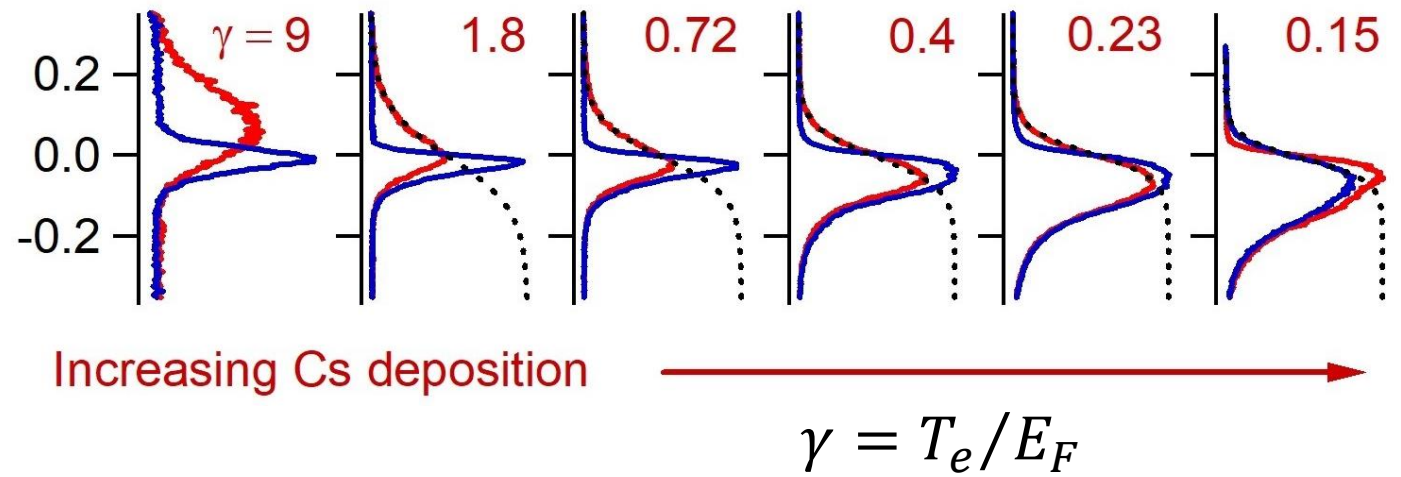
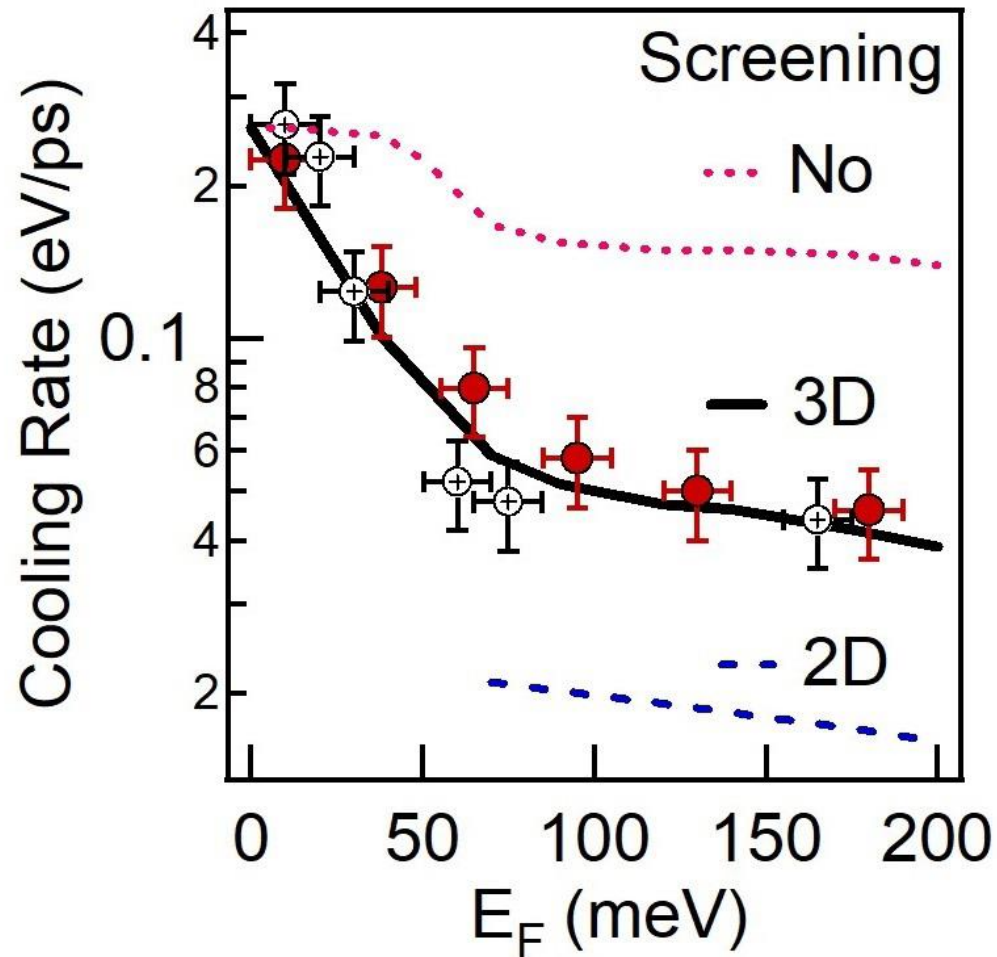
Low deposition:  
photoexcited electrons  
are non-thermal

High deposition:  
photoexcited electrons  
are thermalized

3D Increasing Cs deposition → 2D



# Energy transfer in doped InSe



➡ Remote coupling of electrons to 3D phonons

# Conclusion

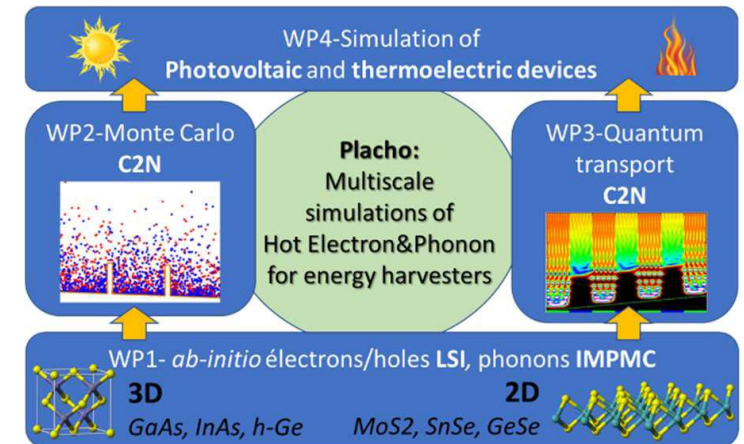
***DFT-based calculations + time-resolved photoemission spectroscopy:  
powerful tools to study electron-phonon coupling***

➡ *The concept of hot electron ensemble allowed us to interpret the relaxation times of highly excited electrons in several semiconductors.*

➡ *Doped InSe:*

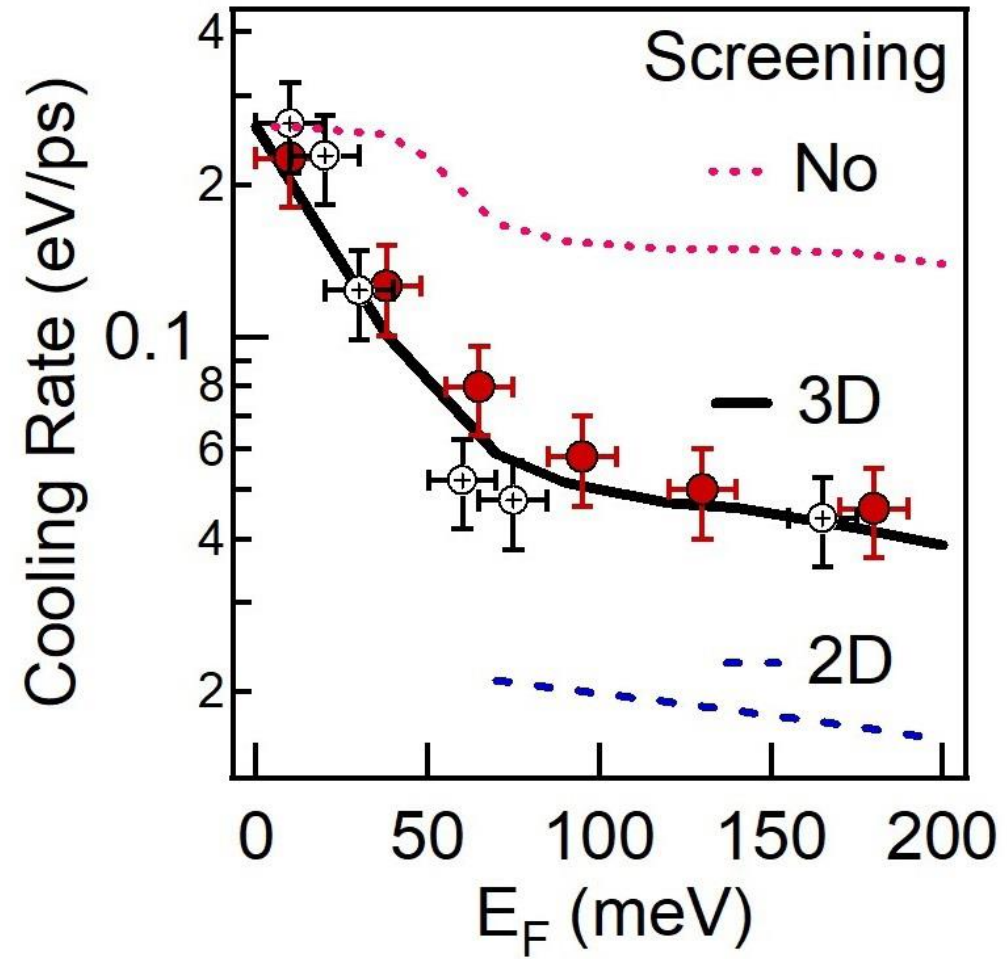
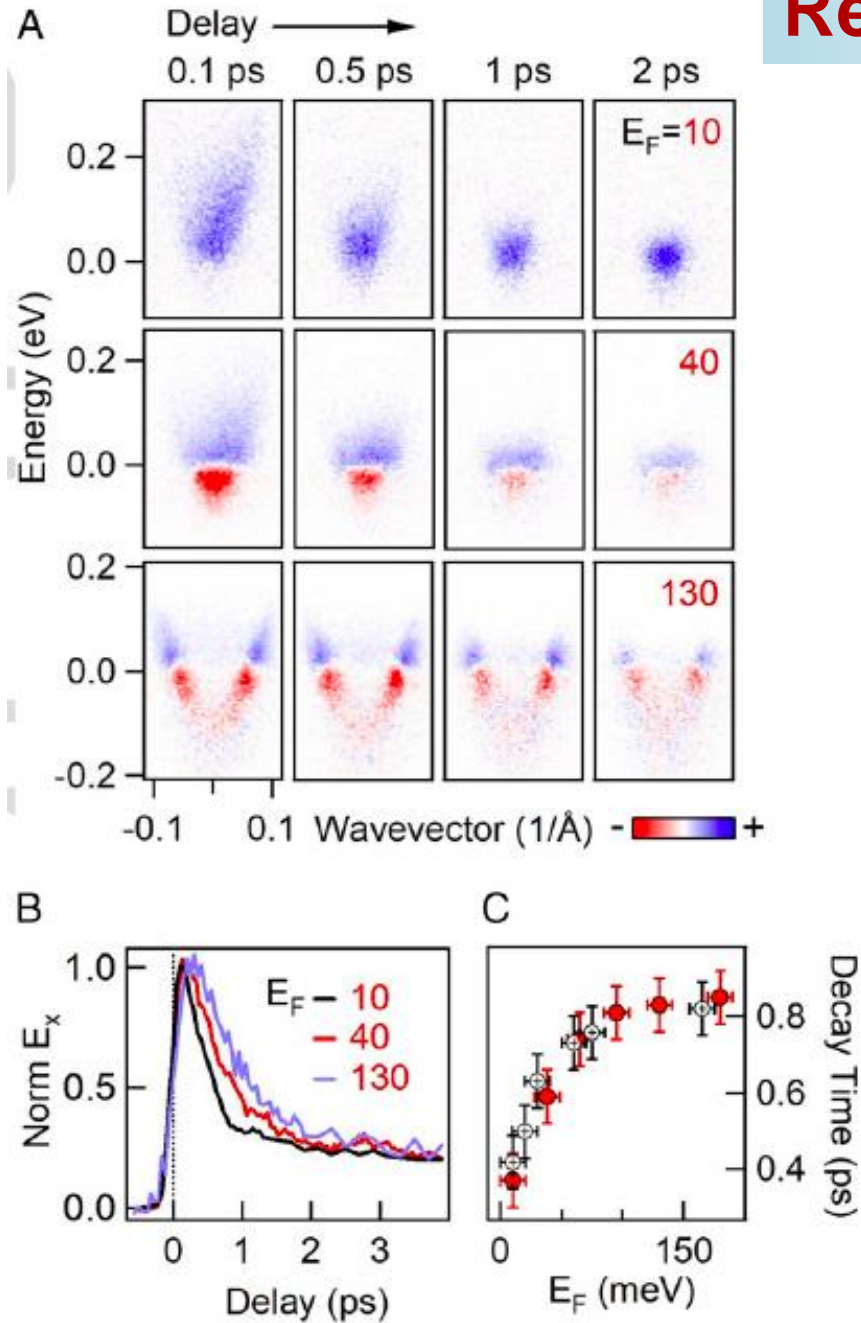
- ➡ *screening of polar coupling*
- ➡ *remote coupling to 3D phonons*

➡ *Hot carrier transport: probing the transient state*

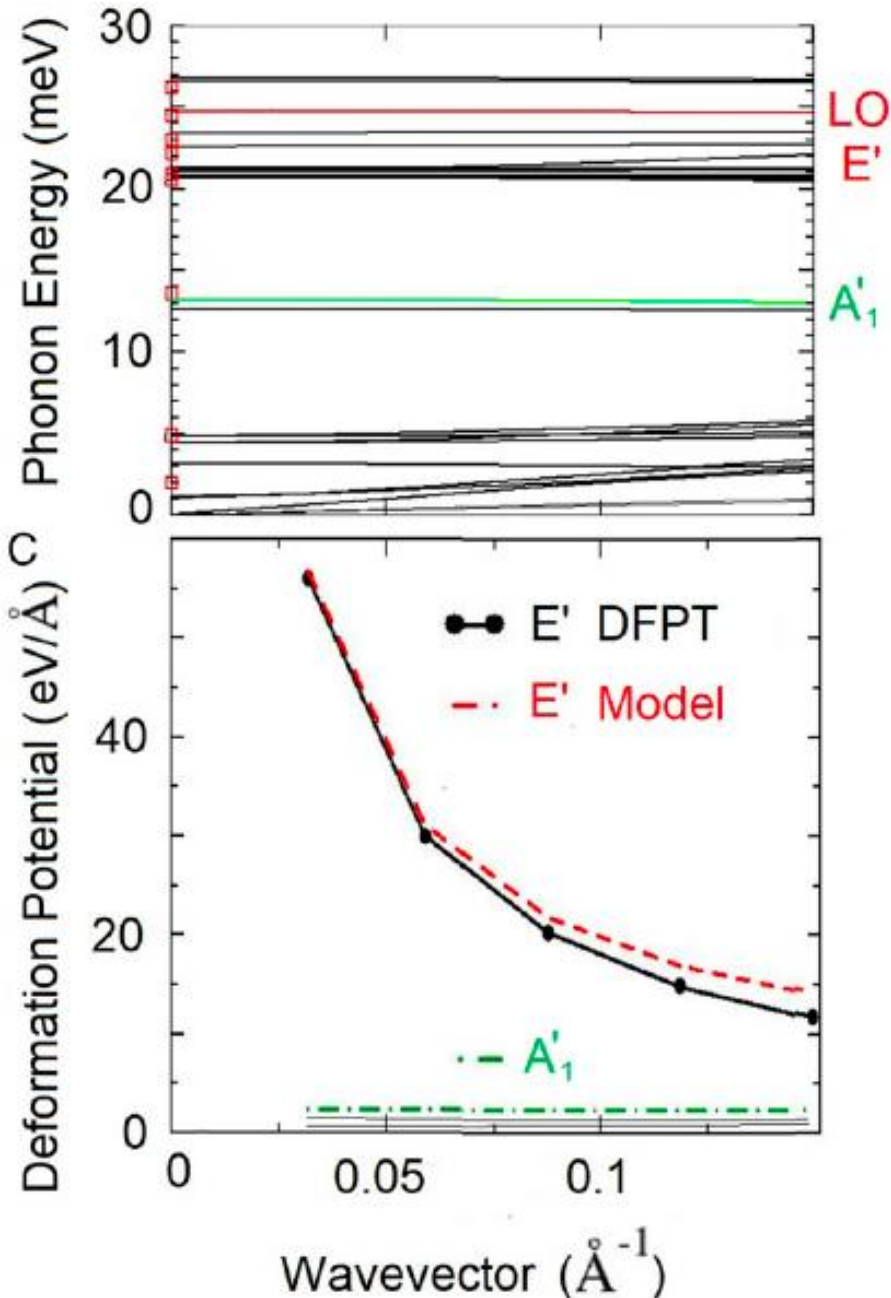


***Thank you for your attention!***

# Relaxation dynamics of photoexcited electrons



# Calculation: screened Fröhlich interaction



## 3D model:

$$|g_{fr}^{3D}(\mathbf{q})| = \frac{4\pi e^2}{V \epsilon_{bulk} |\mathbf{q}|} \sum_s \sum_{\lambda'} \frac{q_{\lambda'}}{|\mathbf{q}|} Z_{\lambda' \lambda s} \mathbf{e}_{\lambda}^s(\mathbf{q}) / \sqrt{2M_s \omega_{\mathbf{q}}}$$

*Vogl, PRB 13 (1976).*

## 3D screening:

$$\epsilon_{bulk}^{scr} = \epsilon_{bulk} \left( 1 + \frac{(q_0^{3D})^2}{q^2} \right)$$

*Thomas-Fermi*

## 2D model:

$$|g_{fr}^{2D}(\mathbf{q})| = \frac{C_Z}{e_{eff}^0 + r_{eff} |\mathbf{q}_p|}$$

$$C_Z = \frac{2\pi e^2}{A} \times \sum_s \sum_{\lambda'} \frac{q_{\lambda'}}{|\mathbf{q}_p|} Z_{\lambda' \lambda s} \mathbf{e}_{\lambda}^s(\mathbf{q}) / \sqrt{2M_s \omega_{\mathbf{q}}}$$

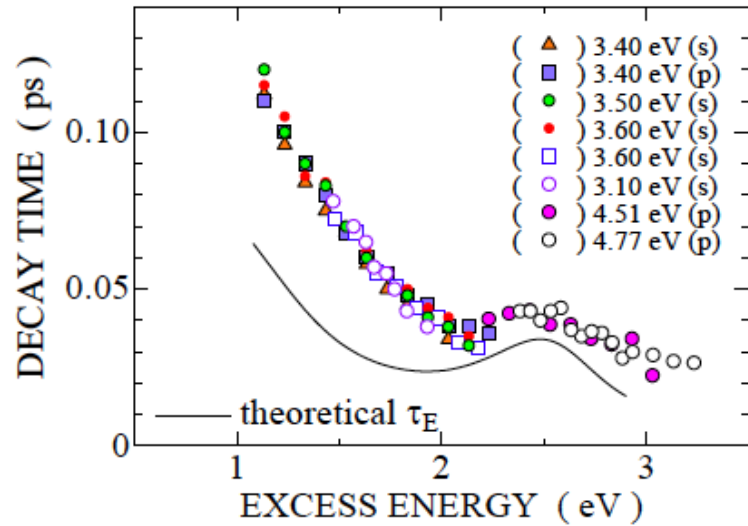
*Sohier, Calandra, Mauri, PRB 94 (2016)*

## 2D screening:

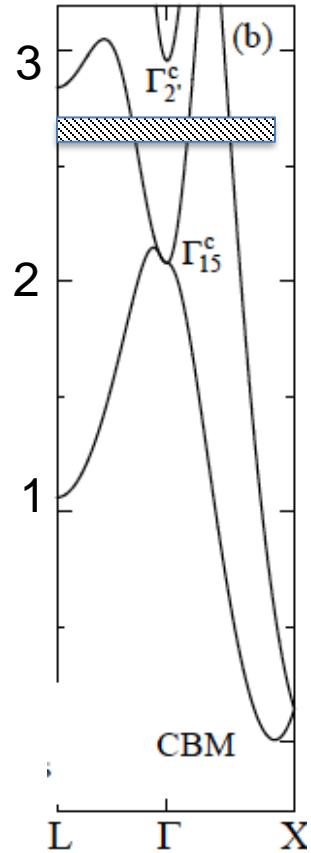
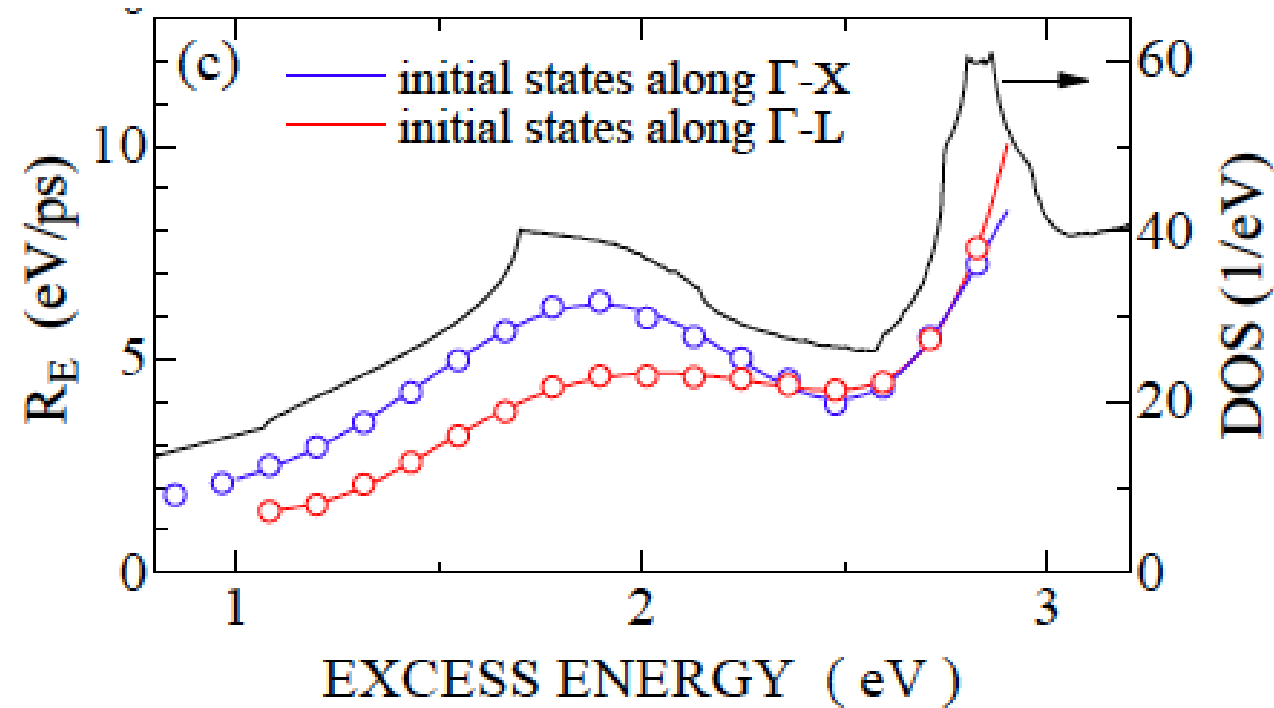
*Stern, PRL 18, 546 (1967)*



# HIGHLY EXCITED ELECTRONS IN SILICON: ENERGY LOSS RATE



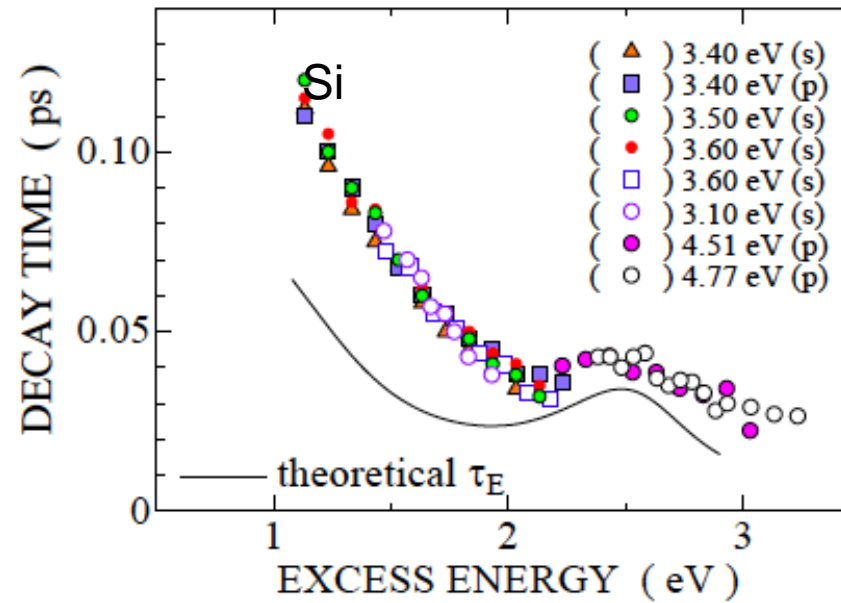
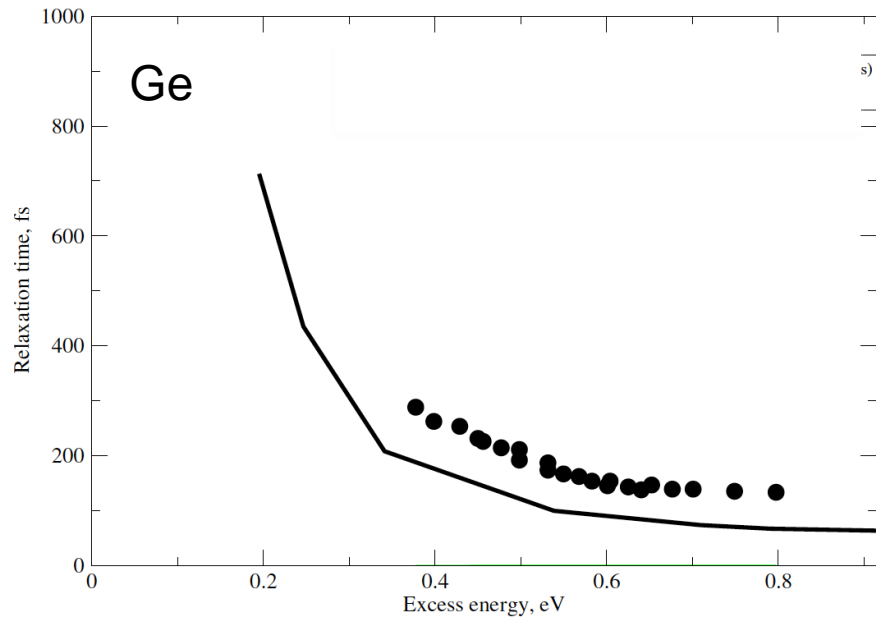
$$\frac{d \langle E \rangle}{dt} = \Gamma_{em} \omega_{em} - \Gamma_{abs} \omega_{abs}$$



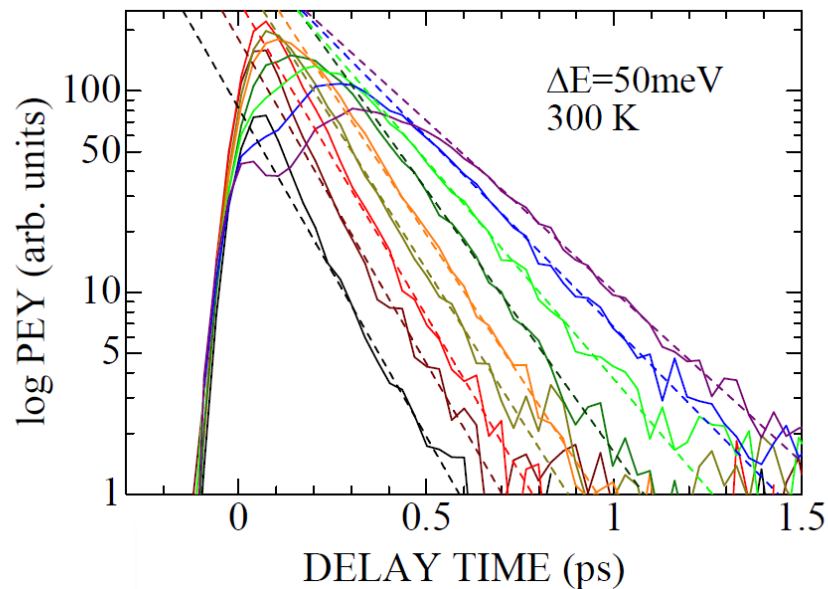
Energy loss rate:

**Determined by DOS of final electronic states**

# THE NEED FOR TIME PROPAGATION



PRB 100, 03520 (2019)



Photoemission intensity (PEY) over energy interval  $\Delta E$ :  
Semi-logarithmic plot analysis, over several hundreds of fs.

# ENERGY-DEPENDENT TIME PROPAGATION MODEL

$$\begin{aligned} \left. \frac{\partial f_{\mathbf{k}n}}{\partial t} \right|_{\text{coll}}^{\text{e-ph}} = & -\frac{2\pi}{\hbar} \frac{1}{L^d} \sum_{\mathbf{q}, \nu} |g_{\mathbf{k}'m, \mathbf{k}n}^\nu|^2 \{ f_{\mathbf{k}n}(1 - f_{\mathbf{k}'m}) N_{\mathbf{q}}^\nu \\ & \times \delta(\varepsilon_{\mathbf{k}n} + \hbar\omega_{\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) + f_{\mathbf{k}n}(1 - f_{\mathbf{k}'m})(1 + N_{-\mathbf{q}}^\nu) \\ & \times \delta(\varepsilon_{\mathbf{k}n} - \hbar\omega_{-\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) - (1 - f_{\mathbf{k}n})f_{\mathbf{k}'m}(1 + N_{\mathbf{q}}^\nu) \\ & \times \delta(\varepsilon_{\mathbf{k}n} + \hbar\omega_{\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) - (1 - f_{\mathbf{k}n})f_{\mathbf{k}'m}N_{-\mathbf{q}}^\nu \\ & \times \delta(\varepsilon_{\mathbf{k}n} - \hbar\omega_{-\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) \}. \end{aligned}$$

$$\longrightarrow \left. \frac{\partial f}{\partial t} \right|_{\text{coll}}(\varepsilon, t)$$

k and q dependent expression can be replaced by excess-energy-dependent model:

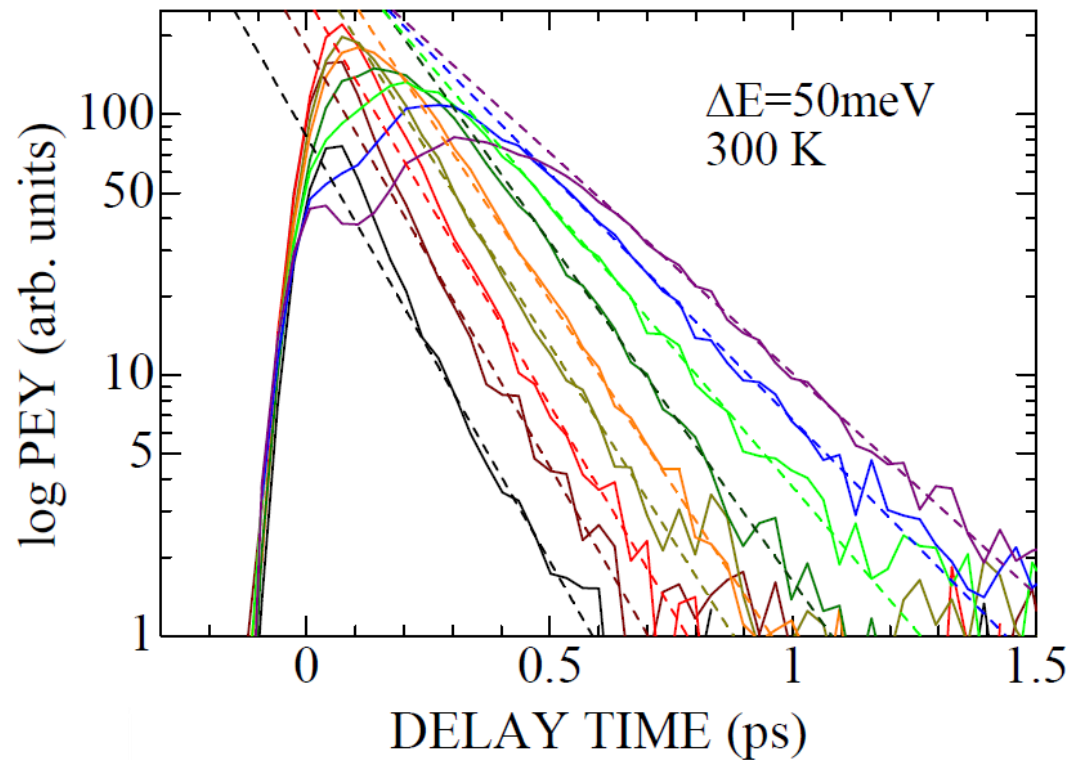
$\text{Dos}(\varepsilon)$ ,  $f(\varepsilon, t)$   $\omega_{em}$ ,  $\omega_{abs}$ ,  $g_{eff}$  (*effective coefficient*)

$$f(\varepsilon, t + \Delta t) = f(\varepsilon, t) \exp(-\Gamma(\varepsilon, t)(t + \Delta t))$$

$$\longrightarrow f(\varepsilon, t + \Delta t) = f(\varepsilon, t) - \Gamma(\varepsilon, t)f(\varepsilon, t)\Delta t$$

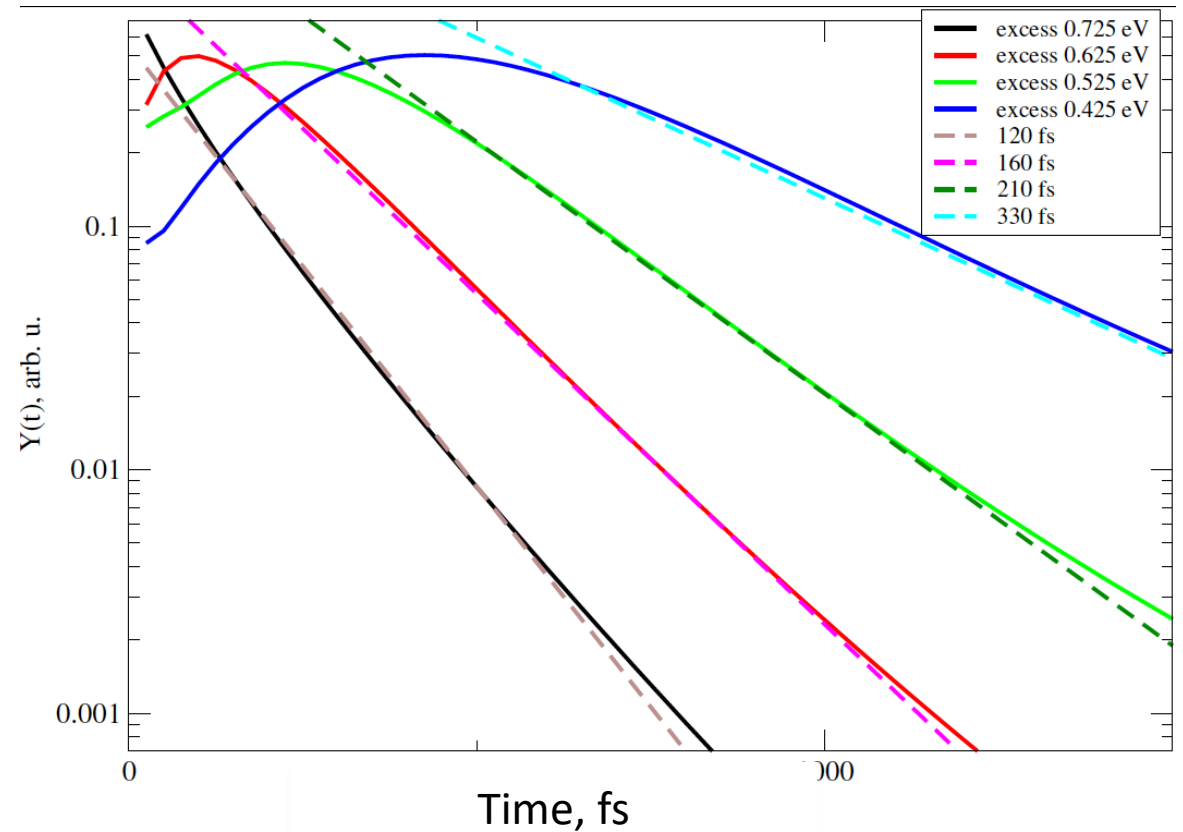
# TIME PROPAGATION OF ELECTRONIC DISTRIBUTIONS

## Experiment



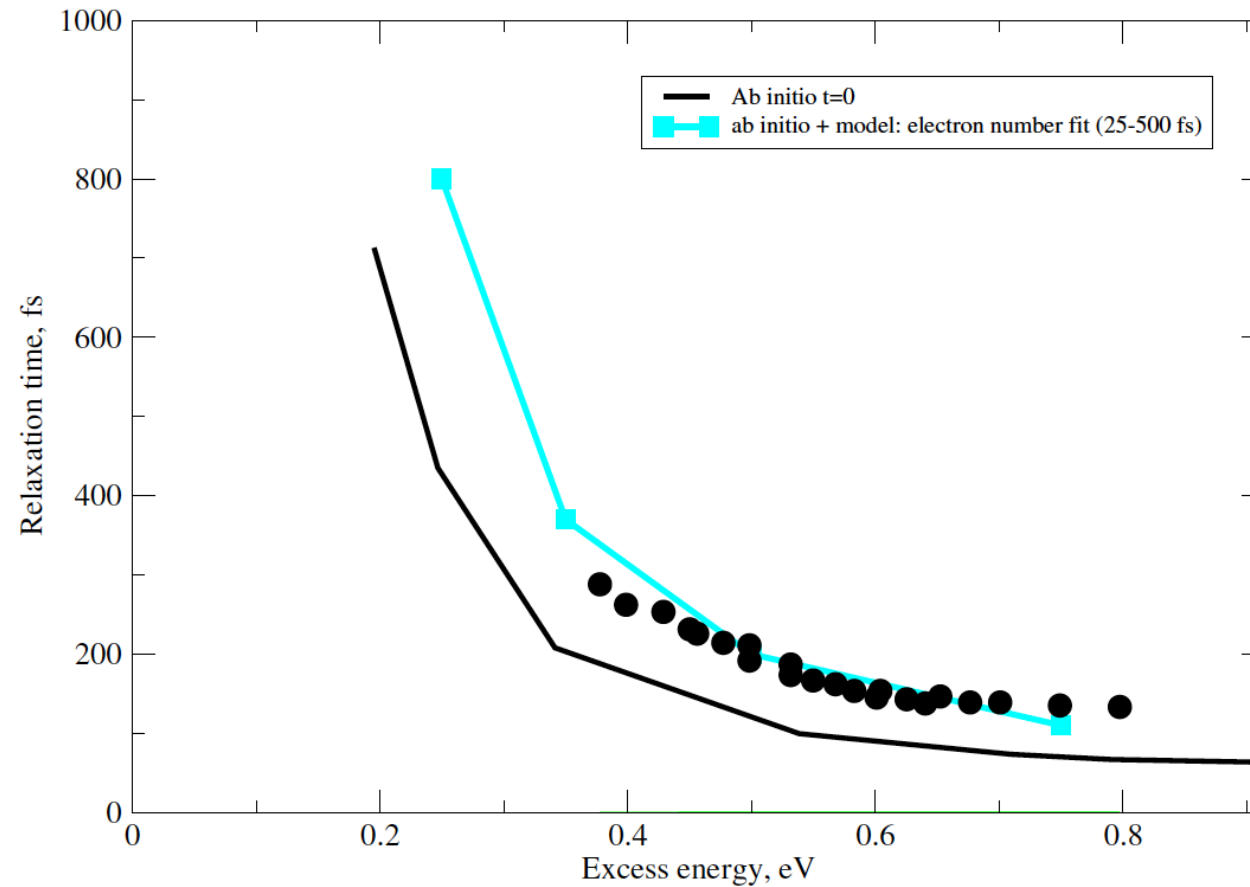
## Theory

$$PEY(E, t) = \int_E^{E+\Delta E} f(\varepsilon, t) n(\varepsilon) d\varepsilon$$




*Semi-logarithmic plot analysis, over several hundred fs.*

# TIME PROPAGATION OF ELECTRONIC DISTRIBUTIONS



Time propagation of electronic distributions allows to improve the theory/experiment agreement

# Outline

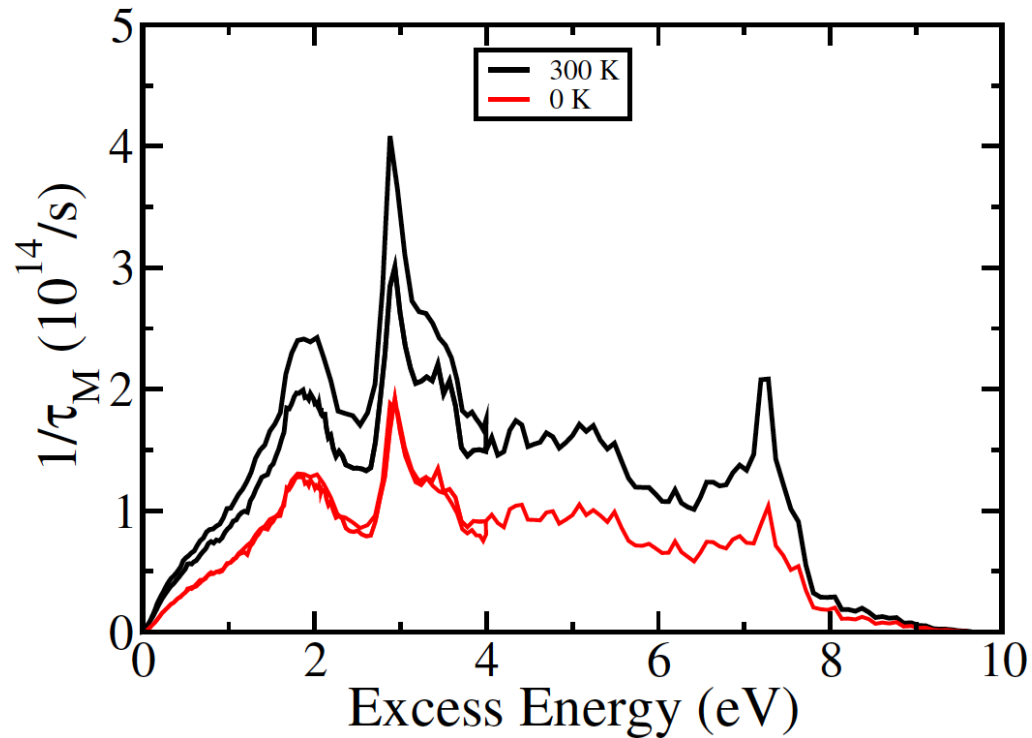
- *Electron-phonon scattering for highly excited electrons*
- *Highly excited electron relaxation in Si and Ge*
- *Time propagation model*
-  - *Photoexcited electron relaxation in InSe*

# TEMPERATURE DEPENDENCE



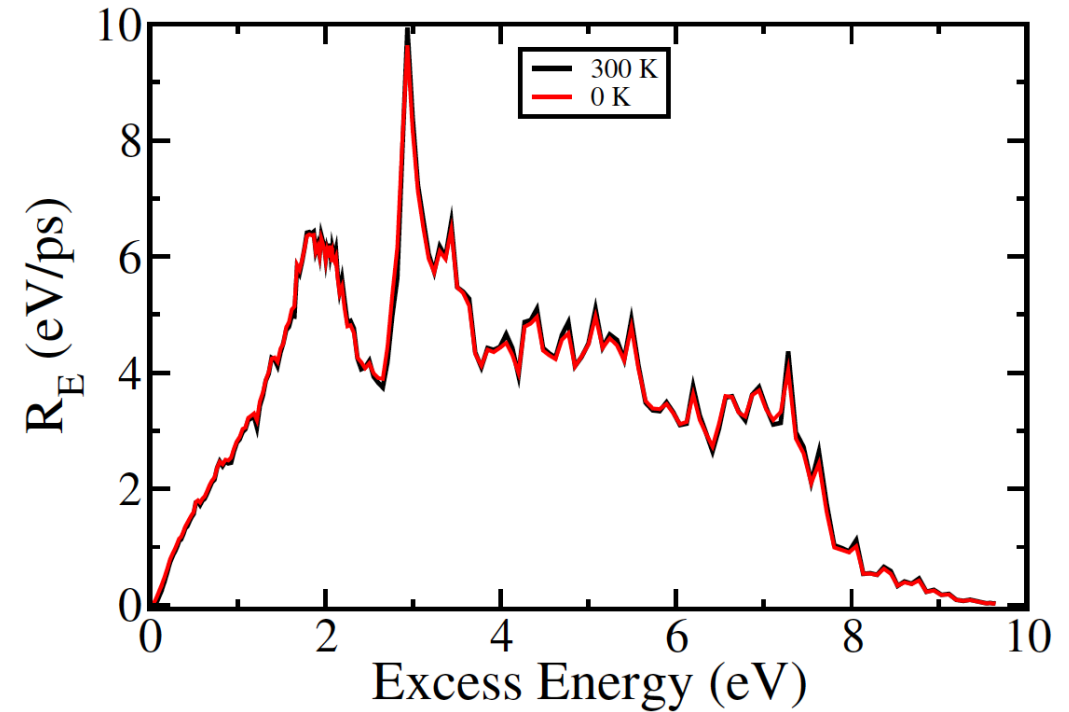
Raja Sen, post-doc

Total scattering rate, Si



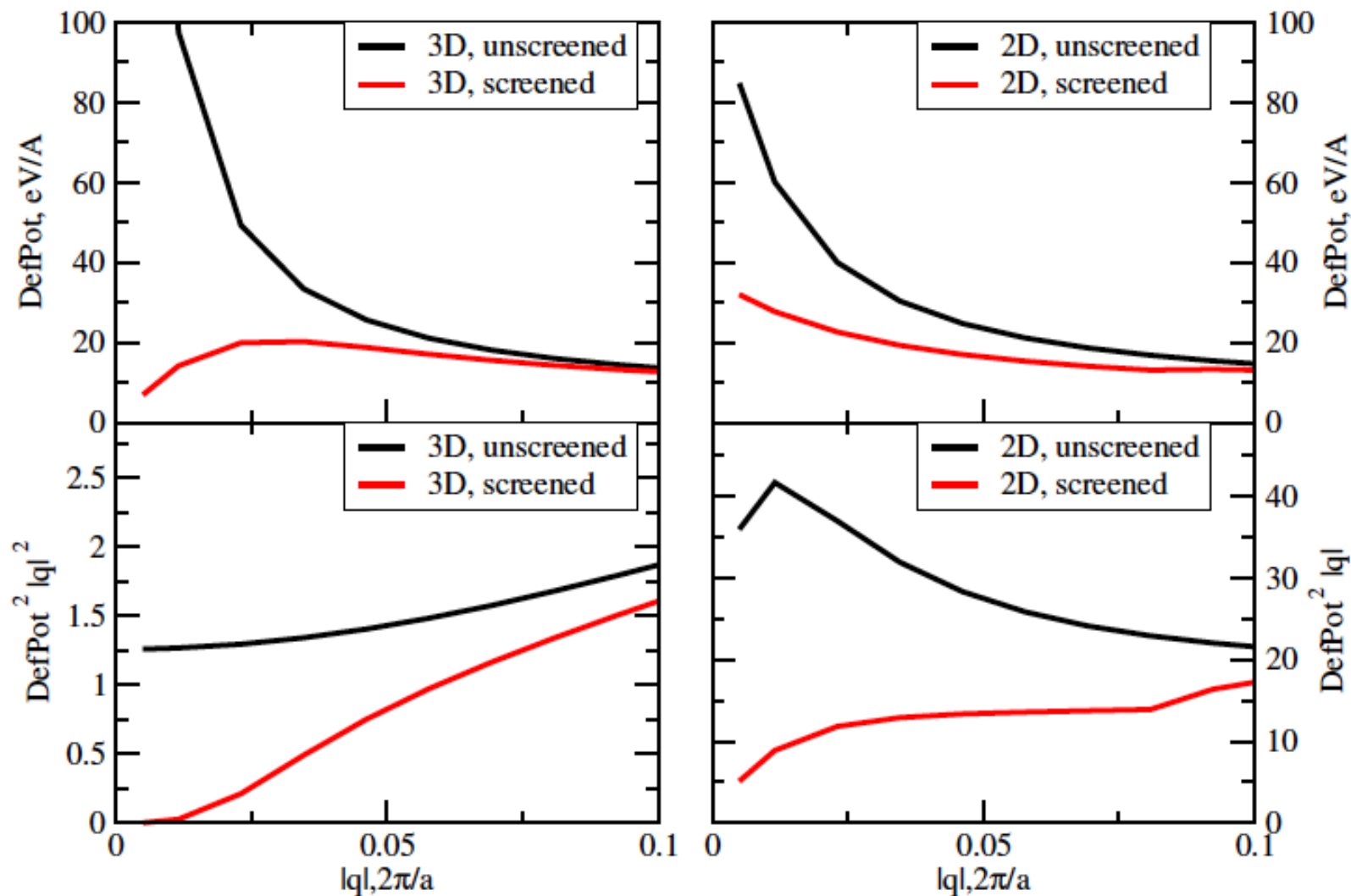
**Populations of acoustical phonons grow with temperature**

Energy loss rate, Si.



**Negligible temperature dependence for energy loss rate**

# The effect of 2D and 3D screening





## Stern model of 2D screening

$$\begin{aligned}\epsilon_{iso}^{scr} &= \epsilon_{iso}(1 + q_0^{2D}/q_p), q_p \leq 2k_F \\ \epsilon_{iso}^{scr} &= \epsilon_{iso}(1 + q_0^{2D}/q_p(1 - (1 - (2k_F/q_p)^2)^{1/2})), \\ &\quad q_p > 2k_F\end{aligned}$$

$$q_0^{2D} = 2m_{eff}e^2/\epsilon_{iso}\hbar^2$$

*Stern, PRL 18, 546 (1967)*

## Excess energy

$$E_x = \frac{\int |f(E, T_e, \mu) - f_0(E, T)| E dE}{\int |f(E, T_e, \mu) - f_0(E, T)| dE}$$

## Energy loss rate:

$$\eta = \frac{d \langle E \rangle}{dt} =$$

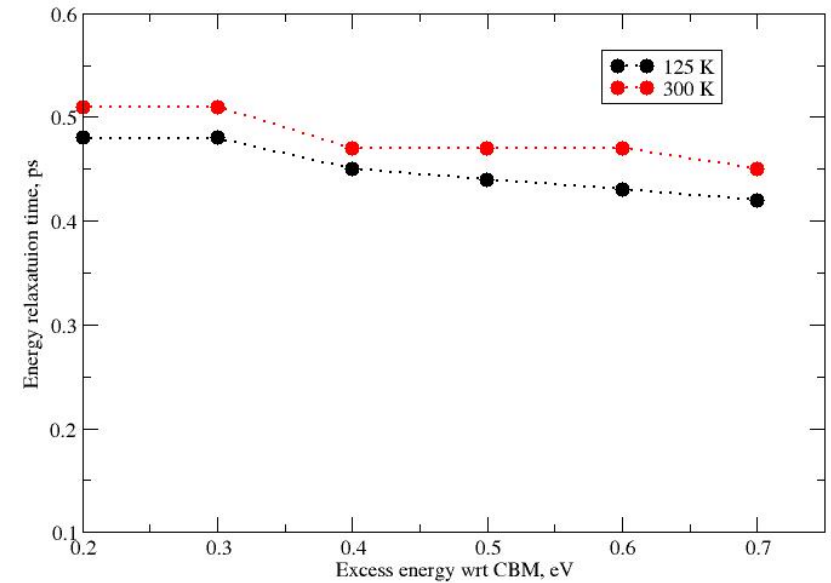
$$\frac{\int |f(E, T_e, \mu) - f_0(E, T)| [(1 - f(E - \hbar\omega_{em}, T_e, \mu))\Gamma_{em}\omega_{em} - (1 - f(E + \hbar\omega_{abs}, T_e, \mu))\Gamma_{abs}\omega_{abs}] dE}{\int |f(E, T_e, \mu) - f_0(E, T)| dE}$$

## Integral mean value theorem:

$$\eta = \frac{d \langle E \rangle}{dt}(E_x) = (1 - f(E_x - \hbar\omega_{em}, T_e, \mu))\Gamma_{em}\omega_{em} - (1 - f(E_x + \hbar\omega_{abs}, T_e, \mu))\Gamma_{abs}\omega_{abs}$$

## Hot electron tail:

$$\frac{d \langle E \rangle}{dt} = \Gamma_{em}\omega_{em} - \Gamma_{abs}\omega_{abs}$$



## Total scattering

$$\Gamma_{n\mathbf{k}}^{em} = \frac{2\pi}{\hbar} \sum_{n'} \sum_{\lambda} \frac{1}{L^d} \sum_{\mathbf{q} \in BZ} |\langle n', \mathbf{k} + \mathbf{q} | \Delta W_{\mathbf{q}}^{\lambda} | n, \mathbf{k} \rangle|^2 \delta(\varepsilon_{n,\mathbf{k}} - \varepsilon_{n',\mathbf{k}+\mathbf{q}} - \hbar\omega_{\mathbf{q}}^{\lambda}) (N_{\mathbf{q}}^{\lambda}(T) + 1)$$

$$\Gamma_{n\mathbf{k}}^{abs} = \frac{2\pi}{\hbar} \sum_{n'} \sum_{\lambda} \frac{1}{L^d} \sum_{\mathbf{q} \in BZ} |\langle n', \mathbf{k} + \mathbf{q} | \Delta W_{\mathbf{q}}^{\lambda} | n, \mathbf{k} \rangle|^2 \delta(\varepsilon_{n,\mathbf{k}} - \varepsilon_{n',\mathbf{k}+\mathbf{q}} + \hbar\omega_{\mathbf{q}}^{\lambda}) N_{\mathbf{q}}^{\lambda}(T)$$

$$\Gamma_{n,\mathbf{k}} = \Gamma_{n\mathbf{k}}^{em} + \Gamma_{n\mathbf{k}}^{abs}$$

# Energy loss

$$\omega_{em}\Gamma_{n,k}^{em} = \frac{2\pi}{\hbar} \sum_{n'} \sum_{\nu} \frac{1}{L^d} \sum_{\mathbf{q} \in BZ} \omega_{\mathbf{q}}^{\nu} |g_{n,k}^{\nu}(\mathbf{q})|^2 \delta(E_{n,k} - E_{n',k+\mathbf{q}} - \hbar\omega_{\mathbf{q}}^{\nu}) (N_{\mathbf{q}}^{\nu}(T) + 1)$$

$$\omega_{abs}\Gamma_{n,k}^{abs} = \frac{2\pi}{\hbar} \sum_{n'} \sum_{\nu} \frac{1}{L^d} \sum_{\mathbf{q} \in BZ} \omega_{\mathbf{q}}^{\nu} |g_{n,k}^{\nu}(\mathbf{q})|^2 \times \delta(E_{n,k} - E_{n',k+\mathbf{q}} + \hbar\omega_{\mathbf{q}}^{\nu}) N_{\mathbf{q}}^{\nu}(T)$$

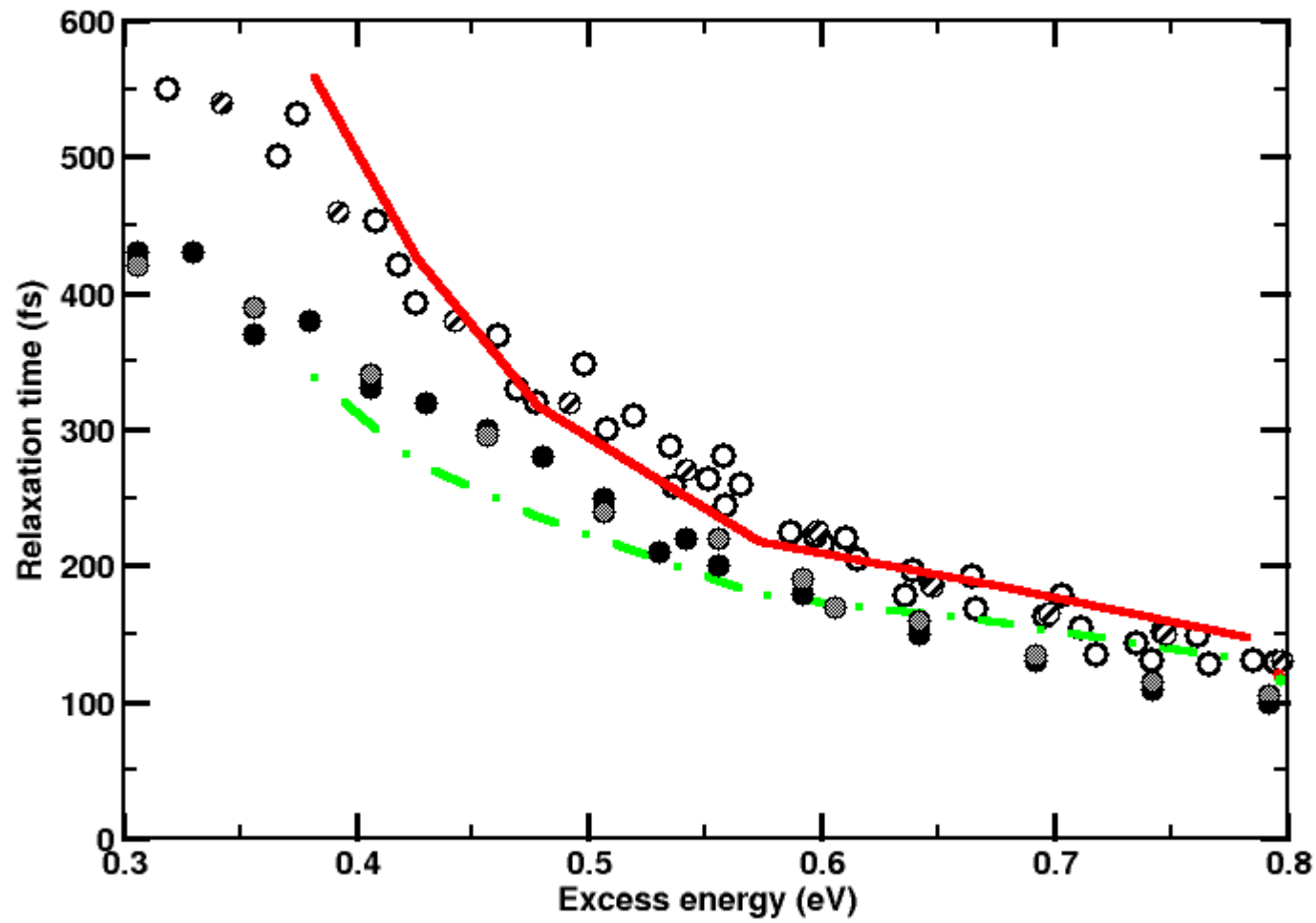
$$\frac{d \langle E \rangle}{dt} = \Gamma_{em}\omega_{em} - \Gamma_{abs}\omega_{abs}$$

Ingredients: dos, matrix elements, phonon frequencies

# Full expression of the collision term: **out** and **in**

$$\begin{aligned}
 \left. \frac{\partial f_{\mathbf{k}n}}{\partial t} \right|_{\text{coll}}^{\text{e-ph}} &= -\frac{2\pi}{\hbar} \frac{1}{L^d} \sum_{\mathbf{q}, \nu} |g_{\mathbf{k}'m, \mathbf{k}n}^\nu|^2 \{ f_{\mathbf{k}n}(1 - f_{\mathbf{k}'m}) N_{\mathbf{q}}^\nu \\
 &\times \delta(\varepsilon_{\mathbf{k}n} + \hbar\omega_{\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) + f_{\mathbf{k}n}(1 - f_{\mathbf{k}'m})(1 + N_{-\mathbf{q}}^\nu) \\
 &\times \delta(\varepsilon_{\mathbf{k}n} - \hbar\omega_{-\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) - (1 - f_{\mathbf{k}n})f_{\mathbf{k}'m}(1 + N_{\mathbf{q}}^\nu) \\
 &\times \delta(\varepsilon_{\mathbf{k}n} + \hbar\omega_{\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) - (1 - f_{\mathbf{k}n})f_{\mathbf{k}'m}N_{-\mathbf{q}}^\nu \\
 &\times \delta(\varepsilon_{\mathbf{k}n} - \hbar\omega_{-\mathbf{q}\nu} - \varepsilon_{\mathbf{k}'m}) \}.
 \end{aligned}$$

# Energy relaxation of hot electrons in GaAs



# ELECTRON-PHONON COUPLING: DFPT

$$\langle \Psi_{n,k} | \Delta W_q^\lambda | \Psi_{n',k+q} \rangle$$

DFPT: Baroni et al, Rev. Mod. Phys. 2001



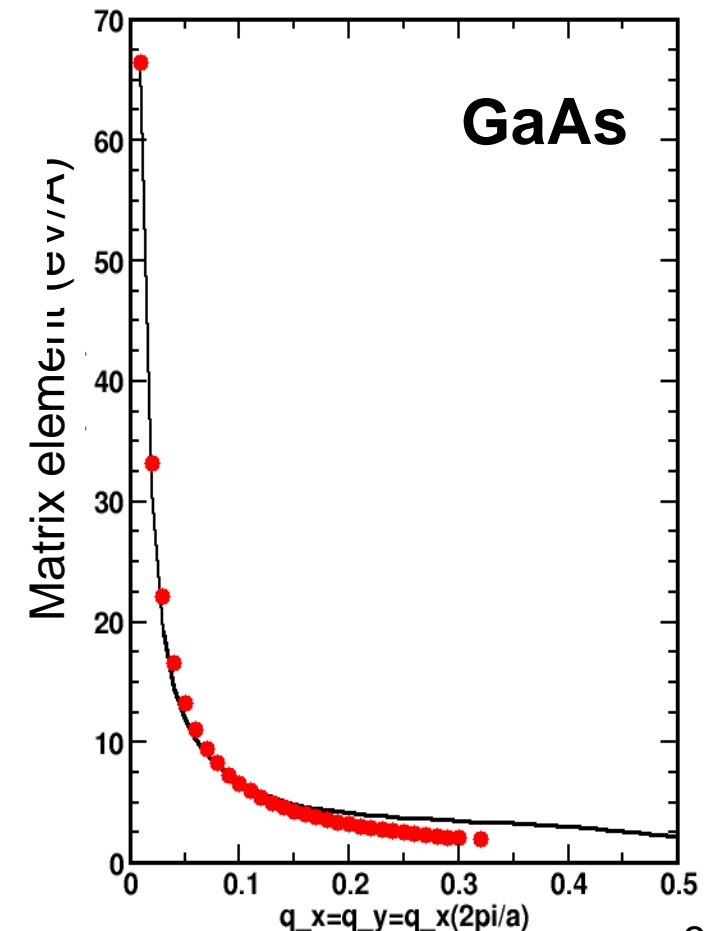
## FRÖHLICH INTERACTION

$$|g_{fr}^{3D}(\mathbf{q})| = \frac{4\pi e^2}{V \epsilon_{bulk} |\mathbf{q}|} \sum_s \sum_{\lambda'} \frac{q_{\lambda'}}{|\mathbf{q}|} Z_{\lambda' \lambda s} \mathbf{e}_{\lambda}^s(\mathbf{q}) / \sqrt{2M_s \omega_{\mathbf{q}}}$$

model based on ab initio parameters:  
dielectric constant , effective charges

Vogl, PRB 13 (1976).

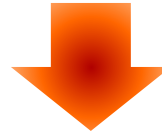
J. Sjakste et al, Annual Review of Heat Transfer, Begell House, Vol. 17 (2014).



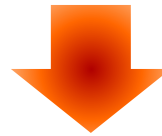
# CALCULATIONS: DFPT+Wannier

Reciprocal space  
Bloch functions  
Initial grid

$$\left\langle \Psi_{n,k} \left| \Delta W_q^\lambda \right| \Psi_{n',k+q} \right\rangle - \text{Non-local part (if polar)}$$



**Real space**  
**Maximally localized Wannier functions**  
**Interpolation on dense grid**



Reciprocal space  
Bloch functions  
Dense grid

$$\left\langle \Psi_{n,k} \left| \Delta W_q^\lambda \right| \Psi_{n',k+q} \right\rangle + \text{Non-local part (if polar)}$$

*J. Sjakste, N. Vast, M. Calandra, F. Mauri, PRB 92 (2015) 054307*

*C. Verdi, F. Giustino, PRL 115 (2015) 176401*







# MAIN CHANNELS: IMPORTANT FOR MONTE CARLO



Raja Sen

“Hot electrons in Si lose energy mostly to optical phonons”: Truth or myth?  

Cite as: Appl. Phys. Lett. **114**, 222104 (2019); doi:10.1063/1.5099914

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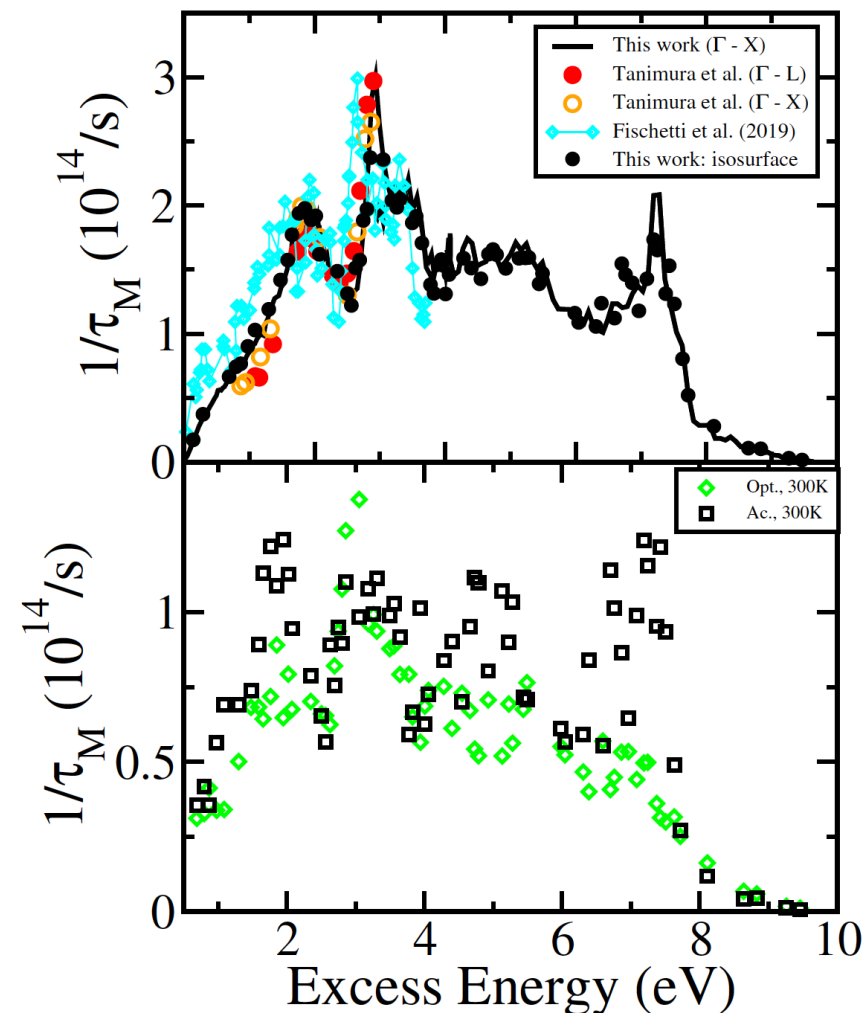
M. V. Fischetti,<sup>1,a)</sup>  P. D. Yoder,<sup>2</sup> M. M. Khatami,<sup>1,3</sup>  G. Gaddemane,<sup>1</sup>  and M. L. Van de Put<sup>1</sup> 

**Total scattering rate:  
acoustical phonons are dominant (at 300K)**

*EPW code, EPIK code: identical results*

*Also: Bernardi et al, PRL (2014)*



Si, 300 K



# MAIN CHANNELS: IMPORTANT FOR MONTE CARLO



Raja Sen





“Hot electrons in Si lose energy mostly to optical phonons”: **Truth** or myth?  

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M. V. Fischetti,<sup>1,a)</sup>  P. D. Yoder,<sup>2</sup> M. M. Khatami,<sup>1,3</sup>  G. Gaddemane,<sup>1</sup>  and M. L. Van de Put<sup>1</sup> 

**Energy loss rate:  
optical phonons are dominant**

Not unexpected:

*Ahmad et al, Phys. Stat. Sol. 40:631 (1970)*

**Temperature-dependent contribution of  
acoustical phonons cancels out of energy loss**

*EPW code, EPIK code: identical results*

